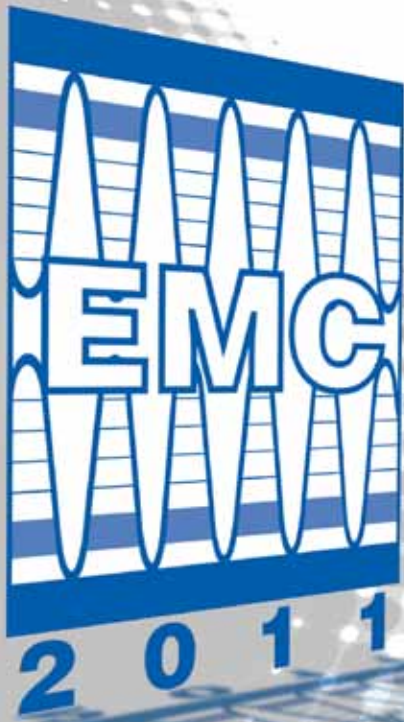


PROGRAM PREVIEW



ELECTRONIC MATERIALS CONFERENCE

and EXHIBITION

June 22-24, 2011

University of California – Santa Barbara
Santa Barbara, California

***53rd Annual Forum on Preparation and
Characterization of Electronic Materials***

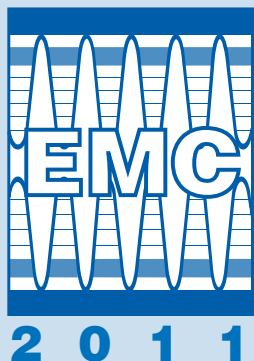
Register by June 3 and save \$100!

Sponsored by

TMS

FOUNDATION

www.tms.org/EMC.html



The Premier 53rd Annual Forum Electronic Materials Conference

June 22-24, 2011

University of California – Santa Barbara
Santa Barbara, California

This is your opportunity to gather with your colleagues during this premier annual forum to advance your work in the electronic materials field.

Expect to network with hundreds of scientists, engineers, researchers, technicians, research and development managers, product managers, and students from around the world who are actively engaged or interested in electronic materials research and development.

EMC 2011 will spotlight both invited and contributed podium presentations on over 30 diverse topics.

Because of the strong interaction between electronic materials and device research, the conference is presented in conjunction with the Device Research Conference (DRC), also held at the University of California – Santa Barbara on June 20-22. This coordination provides an opportunity for the maximum exchange of information between attendees of both conferences.

Register online at www.tms.org/EMC.html by June 3, 2011 and save \$100 off the on-site fee.

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Register by June 3 to Save \$100 Off the On-Site Fee

Visit www.tms.org/EMC.html for secure online registration or to complete the mail-in form

REGISTRATION

Advance Registration Fees

Full Conference	\$460
One Day	\$410
Student	\$205

** Please note the registration fees will increase by \$100 after the June 3 advance registration deadline.*

Your registration fee includes:

- Admission to All Technical Sessions
- Access to the Exhibition
- Wednesday Night Welcoming Reception
- Coffee Breaks
- Gainey Vineyard Event

Value for Your Cost

EMC is being coordinated with the Device Research Conference, also held at the University of California - Santa Barbara from June 20 to 22. Badges will be accepted for admittance to both conferences on Wednesday, June 22.

Refund Policy

A request for a refund due to a cancellation must be made in writing and postmarked no later than June 3, 2011. Mail to: TMS, 184 Thorn Hill Road, Warrendale, PA 15086-7514 USA. A \$75 processing fee is charged for all cancellations. No refunds are issued after the deadline.

PROGRAMMING NOTES

Technical Sessions

The technical program commences with a plenary session on Wednesday, June 22 at 8:30 a.m. in the University/Corwin Pavilion. All sessions are held on the campus of the University of California, Santa Barbara. See page 7 for the preliminary technical program.

Program

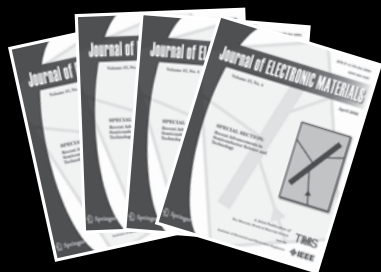
Registrants will receive a complete program at the on-site registration desk containing abstracts of papers presented at the meeting

Late News Papers

Late News Papers will be considered through June 3 and must be submitted by accessing the Abstract Submissions link in the ProgramMaster box.

Audio/Video Recording Policy

TMS reserves the right to all audio and video reproductions of presentations at TMS sponsored meetings. Recording of sessions (audio, video, still photography, etc.) intended for personal use, distribution, publication, or copyright without the express written consent of TMS and the individual authors is strictly prohibited. Contact TMS Technical Programming at (724) 776-9000, ext. 227 to obtain a copy of the waiver release form.



Journal of Electronic Materials Manuscript Submission

JEM employs an on-line manuscript submission and review system. To be considered for publication, authors must submit manuscripts electronically. Detailed submission guidelines are available from the publisher's Web site at <http://www.springer.com/11664>.



ACCOMMODATIONS

Residence Hall

On-campus accommodations will be available on a first-come, first-served basis. Reservations may be made online at http://www.housing.ucsb.edu/conferences/web_reg/drc-emc-housing-2011.htm.

UCSB residence halls and dining facilities are a short walk from the session meeting rooms and the beach. Residence Hall accommodations are either single or double occupancy, with single rooms reserved on a first request basis. Restroom and shower facilities are located on each floor. Lodging includes washcloth/ towel daily room service only. Please book one of the hotel blocks if you will be traveling with children.

If you have questions regarding on-campus housing, please contact:

Sally Vito
Campus Conference Services
University of California
Santa Barbara, CA 93106-6120
Phone: (805) 893-6028
Fax: (805) 893-6018
Email: svito@housing.ucsb.edu

Off-Campus Accommodations

Blocks of rooms have been reserved at special conference rates for the hotels listed below and will be released by mid-May. After that time, reservations can be obtained only on a space available request. Rooms are available for EMC, DRC or both, Sunday through Thursday night if you identify yourself as an attendee. You may also stay Friday or Saturday night if you request it at the time you make your reservations. However, the special rates do not apply to weekend rates. Friday and Saturday rates will be higher.

For additional hotel accommodations, please go to:
www.santabarbaraca.com

The following 3 hotels are located in Goleta approximately 4-5 miles from campus, with a 7-10 minute driving time.

Best Western South Coast Inn (Group Name: DRC/EMC-UCSB)

Phone: (805) 967-3200
\$145 single/double (Sunday – Thursday night)
Rate includes continental breakfast buffet daily and evening hospitality Monday through Thursday. Complimentary shuttle service is available to and from the Santa Barbara Airport.

www.santa-barbara-hotel.com

Holiday Inn (Reservation Code DRC)

Phone: (805) 964-6241
\$139 single/double (Sunday – Thursday night)
Full service restaurant and complimentary airport shuttle between 6 a.m. and 10 p.m.

www.hisantabarbarahotel.com

Pacifica Suites (Group Name: DRC/EMC-UCSB)

Phone: (805) 683-6722
Fax: (805) 683-4121
\$159 single/double (Sunday – Thursday night)
Complimentary cooked-to-order breakfast daily and evening beverages available Monday through Saturday. Complimentary airport shuttle service is offered from 7 a.m. to 7 p.m. with 24-hour notice.

www.pacificasuites.com

The following hotel is located at the beach in Santa Barbara.

Harbor View Inn (Group Name: UCSB DRC/EMC)

Phone: (805) 963-0780
Fax: (805) 963-7967
\$165 single (Sunday to Thursday night)
Combines the intimacy of a Spanish villa with the first-class amenities you expect of a 4-Diamond, luxury hotel. All rooms include a private patio or balcony and added amenities including wireless internet access.

www.harborviewinnsb.com

NETWORKING AND SOCIAL EVENTS

Welcoming Reception

Wednesday, June 22, 6 to 8 p.m. – University Center, Lagoon Plaza

Coffee Breaks

Offered during both morning and afternoon intermissions – University Center, Lagoon Plaza

Gainey Vineyard Event

Thursday, June 23, 6 to 9 p.m. – Gainey Vineyard, Santa Ynez Valley

The 85-acre Gainey Vineyard is located in the heart of Santa Barbara's wine country. Conference attendees will enjoy an evening of great food, fine wine and networking in this beautiful setting.

Tickets are required for guests and attendees registered for only one day of the conference. Tickets are \$70 for adults and \$35 for children 12 and under. Tickets may be purchased on the conference registration form or on-site at the EMC registration desk.

GENERAL INFORMATION

Dress

Casual clothing is appropriate attire, along with a sweater or light jacket occasionally needed for the evenings. Layered clothing is recommended for cooler days or in air-conditioned buildings. Comfortable walking shoes, a light raincoat and an umbrella are also recommended, as the university is essentially a walking campus.

Campus Smoking Policy

The university prohibits smoking in all buildings, including residence halls. Smoking is permitted in designated areas outside and twenty-five feet from structures.

Americans With Disabilities Act



TMS strongly supports the federal Americans with Disabilities Act (ADA) which prohibits discrimination against, and promotes public accessibility for, those with disabilities. In support of, and in compliance with, ADA, we ask those requiring specific equipment or services to indicate their needs on the enclosed housing form or contact TMS Meeting Services in advance.

AWARDS

John Bardeen Award

John Bardeen's career of theoretical and experimental research set the foundation for the current state of understanding of electronic materials. Two areas in which Bardeen had great impact were the invention and development of the solid-state transistor and the theory that developed greater understanding of superconductivity.

Established in 1994, this award recognizes an individual who has made outstanding contributions to, and is a leader in the electronic materials field.



2011 Recipient:

Stephen Pearton,

Professor, University of Florida

Citation: For pioneering advances in the science and application of advanced electronic and photonic device fabrication techniques for compound semiconductor devices used in cell phones, wireless communication systems, collision-avoidance radar, high density DVDs, satellite systems, wireless local area networks, GPS, broadband satellite services and automotive radar-smart-cruise control, traffic lights and other displays.

"TMS is an enormously respected society and the John Bardeen award is one of its premier honors. I am deeply grateful to the society for this recognition and to the collaborators I have worked with over the years at the Australian Atomic Energy Commission, UC Berkeley, Bell Labs and now University of Florida for their many contributions. John Bardeen was one of the greatest scientists of the modern age and the previous winners of this award have all been esteemed leaders in the fields of semiconductors and related materials. I am very pleased and deeply honored to join this select group and to be a proud TMS member."

How to Nominate a Colleague and for Additional Information

Pick up a nomination form at the EMC registration desk, or visit the TMS web site:

www.tms.org/Society/tmsawards.aspx.

ESPECIALLY FOR STUDENTS

EMC Best Student Paper Award

Awards of \$500 each are given to the authors of the best student papers presented at EMC 2011. Student papers are judged on both scientific content and oral presentation. Awards are funded by the TMS Foundation and presented during the plenary session on Wednesday, June 22.

Travel Grants

Student authors who are presenting papers may be eligible for travel assistance. The deadline to apply is June 5. To apply, e-mail Mark Goorsky at goorsky@seas.ucla.edu. Student travel assistance is made possible through generous support from the TMS Foundation.

ATTENTION STUDENTS!

Become a member of the Material Advantage student program for only \$25 and reap the benefits of affiliations with four varied materials organizations!

ACerS: *The American Ceramic Society*

AIST: *Association for Iron & Steel Technology*

ASM: *ASM International*

TMS: *The Minerals, Metals & Materials Society*

For full details on benefits, including scholarships and awards totaling more than \$600,000, visit: www.materialadvantage.org.

MATERIALTM
ADVANTAGE

The Student Program for Materials Science and Engineering

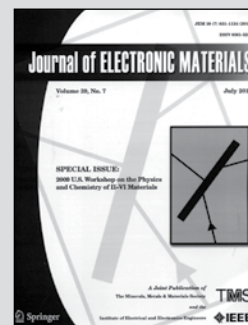
Everything Else Is Immaterial

PROCEEDINGS/PUBLICATIONS

The *Journal of Electronic Materials* (*JEM*) encourages both presenters and attendees of the Electronic Materials Conference to submit manuscripts of their work for an all-EMC special issue at:

www.editorialmanager.com/jems/

The deadline for the all-EMC special issue is **August 1, 2011**.



About *JEM*

JEM is published monthly by The Minerals, Metals & Materials Society (TMS), the Institute of Electrical and Electronics Engineers (IEEE) and Springer Business + Science Media. Articles are reviewed, selected and edited by peers who serve as voluntary members of the editorial board, associate editors, and guest editors. Editor-in-chief: Suzanne Mohney.

JEM's Content

JEM is a forum for the rapid circulation of original research. It contains technical papers detailing critical new developments in the electronic materials field, as well as invited and contributed review articles on topics of current interest. The journal focuses on semiconductors for transistors, detectors, emitters, photovoltaics, and thermoelectrics. It also addresses dielectrics and contact metals, as well as materials for electronic packaging. Additionally, the journal publishes articles on nanofabrication, materials synthesis, crystal growth, electronic properties, optical properties, and reliability.

JEM Subscription

A special *JEM* issue will include manuscripts of papers presented at EMC. Individuals may subscribe to *JEM* by contacting Springer, the journal's publisher:

In North America

Telephone (800) 777-4643

E-Mail journals-ny@springer.com

Outside North America

Telephone (212) 460-1500 or

+49 (0) 6221-345-4303

E-mail subscriptions@springer.com

BUSINESS OPPORTUNITIES

EMC Exhibition

► Wanted: Suppliers of Electronic Materials Technology

Connect with 350 professionals from industry, government laboratories, and academia searching for equipment, instrumentation, software, publications and services in electronic materials:

- Advanced thin-film characterization
- Compound semiconductor materials
- Failure analysis
- GaAs and InP-based epitaxial wafers, substrates
- III-V materials
- Materials characterization
- MOCVD
- Optoelectronics
- Sapphire substrates
- Scanning probe and electron microscopes
- Silicon heterostructures
- Ultra High Purity (UHP) metals, gas and chemical
- Water processing equipment
- Wide bandgap semiconductors

EXHIBIT DATES AND HOURS

Wednesday, June 22 - 9:30 a.m. to 1:30 p.m.;
3 to 4 p.m. and 6 to 8 p.m.

Thursday, June 23 - 10 a.m. to 1:30 p.m.
and 3 to 4 p.m.

What You Receive as an Exhibitor:

- One full-conference registration
- Company listing and link on web site
- Company listing and description in the exhibition directory distributed on-site to all meeting attendees
- Guaranteed traffic with attendee events in exhibit area, including welcoming reception and coffee breaks
- Post-show report of meeting participants
- 8'x10' space (includes six-foot draped table, two chairs, wastebasket, standard electricity)
- Exhibition management services

Your cost: \$1,400 per 8'x 10' space

Space reservations are accepted on a first-come, first-served basis. Book your space online at www.tms.org/EMC.html. Deadline is June 1.

Spotlight Your Company as a Corporate Sponsor!

As the exclusive sponsor of an activity at EMC, your company's name and logo take center stage before an audience of hundreds of professionals through:

Great Visibility Opportunities

- Signage
- Web Site Advertising
- Registration Bags & Lanyards

Exclusive Sponsorship Activities

- Welcoming Reception
- Refreshment Breaks
- Conference Banquet

For more information on sponsorship or the exhibition, contact TMS at:

Telephone (800) 759-4TMS/ (724) 776-9000, ext. 275

E-mail exhibits@tms.org

At-A-Glance

Room	WEDNESDAY		THURSDAY		FRIDAY
	AM	PM	AM	PM	AM
Corwin Pavilion	EMC Student Awards and Plenary Lecture	Registration in the University Center: Tuesday: 3:00 PM to 5:00 PM Wednesday: 7:30 AM to 5:00 PM Thursday: 7:30 AM to 4:00 PM Friday: 7:30 AM to 10:00 AM		Exhibition in University Center/Lagoon Plaza Wednesday: 9:30 AM to 1:30 PM, 3:00 to 4:00 & 6:00 to 8:00 PM Thursday: 10:00 AM to 1:30 PM, 3:00 to 4:00 PM	
Corwin East			Session O: III-Nitrides: UV Emitters and Detectors	Session W: III-Nitride: Bulk Growth and Epitaxy	Session FF: III-Nitrides: Epitaxy Material and Devices II Session GG: Non-Polar and Semi-Polar III-Nitrides Devices
Corwin West			Session P: Oxide Semiconductor Devices	Session X: Oxide Thin Films	Session HH: Oxide Semiconductors: Growth and Doping
Flying A	Session A: III-Nitrides: MBE Growth	Session H: III-Nitrides: Electronics I	Session Q: III-Nitrides: Electronics II	Session Y: Point, Defects, Doping and Extended Defects	Session II: Intersubband Devices: AlInN and InGaN Materials Characterization
Lobero	Session B: Thermoelectrics and Thermionics I	Session I: Thermoelectrics and Thermionics II	Session R: Narrow Bandgap Materials and Devices	Session Z: Epitaxial Materials and Devices I	Session JJ: Compound Semiconductor Growth on Silicon Substrates
Lotte Lehmann	Session C: Nanoscale Characterization	Session J: Nanowire Transport and Devices	Session S: Nanowire Synthesis and Characterization	Session AA: Four Dots and a Dash Session BB: Fundamentals of Low-Dimensional Structures	Session KK: Nanowire Growth and Applications
Multicultural Center Lounge	Session D: Plasmonics and Metamaterials	Session K: Silicon Carbide Growth, Characterization and Devices			
Multicultural Center Theatre	Session E: Organic, Printed and Flexible Electronics	Session L: Graphene Fabrication and Devices	Session T: Growth of Graphene and Carbon Nanotubes	Session CC: Graphene Characterization and Applications	Session LL: Materials Integration: Wafer Bonding and Engineered Substrates
Santa Barbara Harbor	Session F: Devices Utilizing Low Dimensional Structures	Session M: III-Nitrides: Defects and LEDs	Session U: Highly Mismatched Alloys	Session DD: Nano-Magnetic, Magnetic Memory and Spintronic Materials	Session MM: Semiconductor Processing: Oxidation, Passivation, Etching and Contacts
State Street	Session G: Photovoltaics: New Materials and Characterization	Session N: Next Generation Solar Cell Materials and Devices	Session V: Organic Photovoltaics and Photoelectrochemical Cells	Session EE: Organic Thin Film and Crystalline Transistors: Devices and Materials	Session NN: Molecular Electronics / Sensor / Ionic Conductors

Session Listing

TUESDAY, JUNE 21, 2011

Registration 3:00 PM to 5:00 PM University Center

WEDNESDAY, JUNE 22, 2011

Registration 7:30 AM to 5:00 PM University Center

Exhibition 9:30 AM to 1:30 PM, 3:00 to 4:00 & 6:00 to 8:00 PM University Center/Lagoon Plaza

Welcome Reception 6:00 PM to 8:00 PM University Center/Lagoon Plaza

SESSIONS

EMC Student Awards and Plenary Lecture 8:20 AM Corwin Pavilion
Session A: III-Nitrides: MBE Growth 10:00 AM Flying A
Session B: Thermoelectrics and Thermionics I 10:00 AM Lobero
Session C: Nanoscale Characterization 10:00 AM Lotte Lehmann
Session D: Plasmonics and Metamaterials 10:00 AM Multicultural Center Lounge
Session E: Organic, Printed and Flexible Electronics 10:00 AM Multicultural Center Theatre
Session F: Devices Utilizing Low Dimensional Structures 10:00 AM Santa Barbara Harbor
Session G: Photovoltaics: New Materials and Characterization 10:00 AM State Street
Session H: III-Nitrides: Electronics I 1:30 PM Flying A
Session I: Thermoelectrics and Thermionics II 1:30 PM Lobero
Session J: Nanowire Transport and Devices 1:30 PM Lotte Lehmann
Session K: Silicon Carbide Growth, Characterization and Devices 1:30 PM Multicultural Center Lounge
Session L: Graphene Fabrication and Devices 1:30 PM Multicultural Center Theatre
Session M: III-Nitrides: Defects and LEDs 1:30 PM Santa Barbara Harbor
Session N: Next Generation Solar Cell Materials and Devices 1:30 PM State Street

THURSDAY, JUNE 23, 2011

Registration 7:30 AM to 4:00 PM University Center

Exhibition 10:00 AM to 1:30 PM, 3:00 to 4:00 PM University Center/Lagoon Plaza

Banquet 6:00 PM-9:00 PM Gainey Vineyard

SESSIONS

Session O: III-Nitrides: UV Emitters and Detectors 8:20 AM Corwin East
Session P: Oxide Semiconductor Devices 8:20 AM Corwin West
Session Q: III-Nitrides: Electronics II 8:20 AM Flying A
Session R: Narrow Bandgap Materials and Devices 8:20 AM Lobero
Session S: Nanowire Synthesis and Characterization 8:20 AM Lotte Lehmann
Session T: Growth of Graphene and Carbon Nanotubes 8:20 AM Multicultural Center Theatre
Session U: Highly Mismatched Alloys 8:20 AM Santa Barbara Harbor
Session V: Organic Photovoltaics and Photoelectrochemical Cells 8:20 AM State Street
Session W: III-Nitride: Bulk Growth and Epitaxy 1:30 PM Corwin East
Session X: Oxide Thin Films 1:30 PM Corwin West
Session Y: Point, Defects, Doping and Extended Defects 1:30 PM Flying A
Session Z: Epitaxial Materials and Devices I 1:30 PM Lobero
Session AA: Four Dots and a Dash 1:30 PM Lotte Lehmann

Session Listing

THURSDAY, JUNE 23, 2011 *continued*

Session BB: Fundamentals of Low-Dimensional Structures.....	3:30 PM.....	Lotte Lehmann
Session CC: Graphene Characterization and Applications.....	1:30 PM.....	Multicultural Center Theatre
Session DD: Nano-Magnetic, Magnetic Memory and Spintronic Materials.....	1:30 PM.....	Santa Barbara Harbor
Session EE: Organic Thin Film and Crystalline Transistors: Devices and Materials.....	1:30 PM.....	State Street

FRIDAY, JUNE 24, 2011

Registration.....	7:30 AM to 10:00 AM.....	University Center
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SESSIONS

Session FF: III-Nitrides: Epitaxy Material and Devices II.....	8:20 AM.....	Corwin East
Session GG: Non-Polar and Semi-Polar III-Nitrides Devices.....	10:20 AM.....	Corwin East
Session HH: Oxide Semiconductors: Growth and Doping.....	8:20 AM.....	Corwin West
Session II: Intersubband Devices: AlInN and InGaN Materials Characterization.....	8:20 AM.....	Flying A
Session JJ: Compound Semiconductor Growth on Silicon Substrates.....	8:20 AM.....	Lobero
Session KK: Nanowire Growth and Applications.....	8:20 AM.....	Lotte Lehmann
Session LL: Materials Integration: Wafer Bonding and Engineered Substrates.....	8:20 AM.....	Multicultural Center Theatre
Session MM: Semiconductor Processing: Oxidation, Passivation, Etching and Contacts.....	8:20 AM.....	Santa Barbara Harbor
Session NN: Molecular Electronics / Sensor / Ionic Conductors.....	8:20 AM.....	State Street

PRELIMINARY

EMC Student Awards and Plenary Lecture

Wednesday AM Room: Corwin Pavilion
June 22, 2011 Location: University of California-Santa Barbara

8:20 AM Awards Ceremony

8:30 AM Plenary

New Concepts and Materials for Solar Power Conversion: *Wladyslaw Walukiewicz*¹; ¹Lawrence Berkeley National Laboratory

9:20 AM Break

Session A: III-Nitrides: MBE Growth

Wednesday AM Room: Flying A
June 22, 2011 Location: University of California-Santa Barbara

Session Chairs: Michael Manfra, Purdue University; Debdeep Jena, University of Notre Dame

10:00 AM

A1, Nitride Film Growth by Migration Enhanced Afterglow (MEAglow): *K. Scott Butcher*¹; Penka Terziyska¹; DImiter Alexandrov¹; ¹Lakehead University

10:20 AM

A2, Observation and Elimination of Indium Surface Segregation: *Michael Moseley*¹; Brendan Gunning¹; Jonathan Lowder¹; W. Alan Doolittle¹; ¹Georgia Institute of Technology

10:40 AM Student

A3, Depth Resolved Strain and Composition Studies on InGaN and AlInN Films Grown by Plasma-Assisted Molecular Beam Epitaxy: *Wenyuan Jiao*¹; Wei Kong¹; Tongho Kim¹; April Brown¹; ¹Duke University

11:00 AM Student

A4, Low Temperature p-GaN Grown by NH₃-MBE: *Christophe Hurni*¹; Peter Burke¹; Jordan Lang¹; Brian McSkimming¹; Erin Young¹; Umesh Mishra¹; James Speck¹; ¹University of California, Santa Barbara

11:20 AM

A5, Epitaxial Lateral Overgrowth of Aluminum Nitride by Molecular Beam Epitaxy: *Craig Moe*¹; Jonathan Wright¹; Anand Sampath¹; Michael Wraback¹; ¹U.S. Army Research Laboratory

11:40 AM Student

A6, Effect of Superlattices and Surfactants on AlN Homoepitaxy by MBE: *Jai Verma*¹; Guowang Li¹; Debdeep Jena¹; ¹University of Notre Dame

Session B: Thermoelectrics and Thermionics I

Wednesday AM Room: Lobero
June 22, 2011 Location: University of California-Santa Barbara

Session Chairs: Hong Lu, UCSB; Peter Moran, Michigan Technological University

10:00 AM Invited

B1, Phonon Engineering through Crystal Chemistry: *Eric Toberer*¹; Alex Zevalkink²; G. Jeffrey Snyder²; ¹Colorado School of Mines; ²Caltech, Materials Science

10:40 AM Student

B2, Ca₃AlSb₃ and Ca₅Al₂Sb₆; Inexpensive, Non-Toxic Thermoelectric Materials for Waste Heat Recovery: *Alex Zevalkink*¹; Eric Toberer¹; Wolfgang Zeier¹; Espen Flage-Larsen²; Jeff Snyder¹; ¹Caltech; ²University of Oslo

11:00 AM

B3, The Impact of Nano-Inclusions Introduced by Mechanical Alloying on Thermoelectric Transport in Pb_{1-x}Sn_xTe: Experimental Results and Theoretical Predictions: *Lakshmi Krishna*¹; ¹Michigan Technological University

11:20 AM

B4, Reevaluation of PbTe_{1-x}I_x as High Performance n-Type Thermoelectric Material: *Aaron LaLonde*¹; Ynzhong Pei¹; G. Jeffrey Snyder¹; ¹California Institute of Technology

11:40 AM

B5, The Universal Optimal Seebeck Coefficient for Maximum Power Factor: *Paothep Pichanusakorn*¹; Prabhakar Bandaru¹; ¹UCSD

Session C: Nanoscale Characterization

Wednesday AM Room: Lotte Lehmann
June 22, 2011 Location: University of California-Santa Barbara

Session Chair: Suneel Kodambaka, University of California, Los Angeles (UCLA)

10:00 AM Student

C1, Scanning Gate Spectroscopy: A New SPM Technique for Nano-Devices on Oxide Surfaces: *Steven Hunt*¹; Elliot Fuller¹; Brad Corso¹; Phil Collins¹; ¹Department of Physics and Astronomy, Univ. of California at Irvine

10:20 AM

C2, Measurement of Nanoscale External Quantum Efficiency of Plastic Solar Cells by Photoconductive Atomic Force Microscopy: *Xuan-Dung Dang*¹; Thuc-Quyen Nguyen¹; Alexander Mikhailovskiy¹; ¹UCSB

10:40 AM

C3, Role of Ethylene on Thermal and Chemical Stability of TiO₂(110): *Yuya Murata*¹; Vania Petrova²; Ivan Petrov²; Suneel Kodambaka¹; ¹University of California, Los Angeles (UCLA); ²Frederick-Seitz Materials Research Laboratory, University of Illinois Urbana-Champaign

11:00 AM

C4, Combined XSTM and High Resolution XRD Study for Quantitative Structural Descriptions of Type-II Superlattice IR Detectors: *Michael Yakes*¹; Syed Qadri¹; Kevin Matney²; Changyun Yi¹; Ed Aifer¹; ¹Naval Research Laboratory; ²Jordan Valley Semiconductors

11:20 AM Student

C5, In Situ Transmission Electron Microscopy and Photoluminescence Study of Ge-Core/SiGe-Shell Nanowires: *Shu Hu*¹; Yoko Kawamura²; Kevin Huang¹; Irene Goldthorpe¹; Ann Marshall¹; Mark Brongersma¹; Paul McIntyre¹; ¹Stanford University; ²Keio University

11:40 AM Student

C6, Local Strain Characterization of MEMS-Based Silicon Beams by Raman Spectroscopy: *Ferran Ureña*¹; Sarah Olsen¹; Enrique Escobedo-Cousin¹; Lidija Siller¹; Umesh Bhaskar²; Jean-Pierre Raskin²; ¹Newcastle University; ²Université catholique de Louvain

Session D: Plasmonics and Metamaterials

Wednesday AM Room: Multicultural Center Lounge
June 22, 2011 Location: University of California-Santa Barbara

Session Chair: Rachel Goldman, Univ of Michigan

10:00 AM Student

D1, Tuning of Plasmonic Cavity Resonances Using Atomic Layer Deposition: *Yan Mui Kitty Yeung*¹; Kasey Russell¹; Evelyn Hu¹; ¹Harvard University

10:20 AM

D2, Tunable Infrared Absorption of Nano Plasmonic Structures: *Naresh Das*¹; Wayne Chang¹; ¹Army Research Laboratory

10:40 AM

D3, In Situ Spectroscopic Ellipsometric Analysis of Thin Silver Films Deposited Using DC Magnetron Sputtering and HiPIMS Techniques: *Lirong Sun*¹; Neil Murphy¹; Adam Waite¹; John Jones¹; Rachel Jakubiak¹; ¹Air Force Research Laboratory

11:00 AM Invited

D4, Second Harmonic Generation in a Metamaterial Resonating at Fundamental and Second Harmonic Frequencies: Yasuhiro Tamayama¹; Tetsuo Kanazawa¹; Toshihiro Nakanishi¹; Masao Kitano¹; Akio Sasaki¹; ¹Kyoto University

11:40 AM Student

D5, Optical Dispersion of Amorphous Germanium Thin Films as a Function of Thickness and Deposition Parameters: *Neil Murphy*¹; Lirong Sun¹; Adam Waite¹; John Jones¹; Rachel Jakubiak¹; ¹Air Force Research Laboratory

Session E: Organic, Printed and Flexible Electronics

Wednesday AM Room: Multicultural Center Theatre
June 22, 2011 Location: University of California-Santa Barbara

Session Chairs: William Wong, University of Waterloo; Oana Jurchescu, Wake Forest University

10:00 AM

E1, Quantum Dot Red/Green/Blue/White Light-Emitting Electroluminescent Devices with a Low Turn-on Voltage and High Brightness: *Seonghoon Lee*¹; ¹Seoul National University

10:20 AM Student

E2, Fabrication of Flexible Single-Crystal Devices on Electrically-Conductive Substrates: *C. Doran*¹; W. Chen¹; K. Henttinen²; T.L. Alford³; S.S. Lau¹; ¹Department of Electrical and Computer Engineering, University of California, San Diego; ²Okmetic Oyj; ³School for Engineering of Matter, Transport and Energy, Arizona State University

10:40 AM

E3, A Compensation Mechanism for Flexible and Electrically Stable Solution-Processed Organic Field-Effect Transistors: *Do Kyung Hwang*¹; Canek Fuentes-Hernandez¹; Junbae Kim¹; William Potscavage¹; Bernard Kippelen¹; ¹Georgia Institute of Technology

11:00 AM

E4, On the Correlation between Structure, Morphology, and Charge Transport in Organic Molecular Films: The Tetracene Case: Giuseppe Tarabella¹; Simone Bertolazzi²; Julia Wuensche²; Luca Lutterotti³; Fabio Cicoira¹; *Clara Santato*²; ¹CNR; ²École Polytechnique de Montréal; ³Università di Trento

11:20 AM Student

E5, Application of Vapor Forms 1-Octanethiol Coated Copper Conductive Ink for Ink-Jet Printing: *Shinyoung Park*¹; Jinhyeong Kwon¹; Jaehak Her¹; Md. Mominul Haque¹; Young-Suk Kim²; Caroline Sunyong Lee¹; ¹Hanyang University; ²Korea Electronics Technology Institute

11:40 AM E6, Late News

Session F: Devices Utilizing Low Dimensional Structures

Wednesday AM Room: Santa Barbara Harbor
June 22, 2011 Location: University of California-Santa Barbara

Session Chairs: Diana Huffaker, University of California, Los Angeles; James Merz, University of Notre Dame

10:00 AM Student

F1, Design and Growth of InAs Quantum Dash Based MWIR VECSELS: *Victor Patel*¹; Simon Reissmann¹; Thomas Rotter¹; Pankaj Ahirwar¹; Stephen Clark¹; Alexander Albrecht¹; Huiwen Xu¹; Christopher Hains¹; Larry Dawson¹; Ganesh Balakrishnan¹; ¹Center For High Technology Materials (CHTM), University of New Mexico

10:20 AM Student

F2, Influence of Surface Patterning on Droplet Epitaxy and Photovoltaic Properties of InAs/GaAs Quantum Dots: *Simon Huang*¹; Jia-Hung Wu¹; Rachel Goldman¹; ¹University of Michigan, Ann Arbor

10:40 AM Student

F3, Novel 3-State Quantum Dot Gate FET in Silicon-on-Insulator Substrate: *Supriya Karmakar*¹; John A Chandy¹; Faquir C Jain¹; ¹University of Connecticut

11:00 AM Student

F4, Visible Light Emitting Diodes Based on Self-Assembled In_{0.5}Ga_{0.5}As Quantum Dots on GaP: *Yuncheng Song*¹; Paul Simmonds¹; Minjoo Lee¹; ¹Yale University

11:20 AM Student

F5, Large Area Growth of GaAs Solar Cell Based on Nanowire Structure: *Chun-Yung Chi*¹; Anuj Madaria¹; Maoqing Yao¹; Ruijuan Li¹; Chongwu Zhou¹; Pael Dapkus¹; ¹University of Southern California

11:40 AM Student

F6, Output Polarization Dependence of Asymmetric Current Injection VCSELS on Crystalline Direction and Ion Implantation: *Yan Zheng*¹; Chin-Han Lin¹; Matthias Gross²; Larry Coldren¹; ¹University of California Santa Barbara; ²Ziva Corporation

Technical Program

Session G:

Photovoltaics: New Materials and Characterization

Wednesday AM
June 22, 2011

Room: State Street
Location: University of California-Santa Barbara

Session Chairs: Jerry Woodall, Purdue University; David Janes, Purdue University

10:00 AM Student

G1, Molecular Beam Epitaxial Growth of Zn_3P_2 /GaAs and ZnS/GaAs Heterostructures for Photovoltaics: *Jeffrey Bosco*¹; Gregory Kimball¹; Harry Atwater¹; ¹California Institute of Technology

10:20 AM

G2, $ZnSnN_2$: A New Earth-Abundant Semiconductor for Solar Energy Conversion: *Lise Lahourcade*¹; Naomi Coronel¹; Harry Atwater¹; ¹California Institute of Technology

10:40 AM Student

G3, Electrodeposition of Indium Sulfide Films from Organic Electrolytes: Robert Engelken¹; Jason Newell¹; *Maqsood Mughal*¹; John Hall¹; Joshua Vangilder¹; Frederick Felizco¹; ¹Arkansas State University

11:00 AM

G4, Investigation of Bandgap Electronic States in Cadmium Telluride Solar Cells by Impedance Spectroscopy: *Behrang Hamadani*¹; Nhan Nguyen¹; Nikolai Zhitenev¹; Alec Talin¹; Michelle Sestak²; David Gundlach¹; Robert Collins²; ¹National Institute of Standards and Technology; ²University of Toledo

11:20 AM Student

G5, Spatially Resolved Responses of Nanoscale Photovoltaic Model Devices: *Thomas Dufaux*¹; Jens¹; Jens Dorfmueller¹; Ralf Vogelgesang¹; Marko Burghard¹; Klaus Kern¹; ¹Max Planck Institute for Solid State Research

11:40 AM

G6, Challenges of Hall Measurements on Low Mobility Materials and How to Overcome Them: *Jeffrey Lindemuth*¹; Shin Mizuta²; ¹Lake Shore Cryotronics; ²Toyo Corp

Session H:

III-Nitrides: Electronics I

Wednesday PM
June 22, 2011

Room: Flying A
Location: University of California-Santa Barbara

Session Chairs: Edwin Piner, Texas State University; Michael Manfra, Purdue University

1:30 PM Student

H1, Quantization and Bias Effects on Gate Capacitance of Scaled GaN HFETs: *Vincent Lee*¹; Atsushi Ohoka¹; Lingquan Wang¹; Peter Asbeck¹; ¹University of California, San Diego

1:50 PM Student

H2, Direct Correlation between E_c -0.57 eV Trap Generation and Field-Induced Degradation in AlGaIn/GaN High Electron Mobility Transistors: *Anup Sasikumar*¹; Aaron Arehart¹; Stephen Kaun²; Man Hoi Wong²; James Speck²; Umesh Mishra²; Steven Ringel¹; ¹The Ohio State University; ²University of California, Santa Barbara

2:10 PM Student

H3, Temperature Dependent Off-State Degradation of AlGaIn/GaN HEMTs: *Erica Douglas*¹; C. Y. Chang¹; Lu Liu¹; S. J. Pearton¹; F. Ren¹; ¹University of Florida

2:30 PM

H4, Noise Measurements of Nanowire FET Sensors for Sensitivity Determination: Devin Rourke¹; *Mary Rowe*¹; Paul Blanchard¹; Aric Sanders¹; Kristine Bertness¹; Norman Sanford¹; ¹NIST Boulder

2:50 PM Student

H5, Piezoresistive Microcantilever with Embedded AlGaIn/GaN HFET for Sensing Applications: Muhammad Qazi¹; Md. Noman¹; *Goutam Koley*¹; ¹Department of Electrical Engineering, University of South Carolina, Columbia, SC29208, USA

3:10 PM Break

3:30 PM Student

H6, N-Polar GaN HEMTs Grown by MBE and MOCVD with f_{max} of 255 and 250 GHz, Respectively: *Dan Denninghoff*¹; Sansaptak Dasgupta¹; Jing Lu¹; David Brown²; Stacia Keller¹; Jim Speck¹; Umesh Mishra¹; ¹University of California Santa Barbara; ²HRL

3:50 PM Student

H7, Flattened Transconductance (g_m) in a Highly Scaled AlGaIn/GaN HEMT Using a Polarization-Induced 2D/3D Hybridized Channel Design: *Pil Sung Park*¹; Digbijoy Nath¹; Sriram Krishnamoorthy¹; Siddharth Rajan¹; ¹The Ohio State University

4:10 PM

H8, Fabrication of AlGaIn/GaN Transistors with f_t and f_{max} Exceeding 100 GHz: Taek Lim¹; *Patrick Waltereit*¹; Rolf Aidam¹; Rüdiger Quay¹; Lutz Kirste¹; Peter Brückner¹; Rudolf Kiefer¹; Oliver Ambacher¹; ¹Fraunhofer IAF

4:30 PM Student

H9, Effects of Threading Dislocation Density on the Gate Leakage of AlGaIn/GaN Heterostructures for High Electron Mobility Transistors: *Stephen Kaun*¹; Man Hoi Wong¹; Sansaptak Dasgupta¹; Soojeong Choi¹; Umesh Mishra¹; James Speck¹; ¹University of California, Santa Barbara

4:50 PM Student

H10, Growth and Characterization of npn-GaN/InGaIn/GaN Double-Heterojunction Bipolar Transistors on a Free-Standing GaN Substrate: *Zachary Lochner*¹; Hee Jin Kim¹; Yun Zhang¹; Suk Choi¹; Yi-Che Lee¹; Jae-Hyun Ryou¹; Shyh-Chiang Shen¹; Russell D. Dupuis¹; ¹Georgia Institute of Technology

Session I:

Thermoelectrics and Thermionics II

Wednesday PM
June 22, 2011

Room: Lobero
Location: University of California-Santa Barbara

Session Chairs: Lakshmi Krishna, Michigan Technological University; Joshua Zide, University of Delaware

1:30 PM

I1, A Tubular Thermoelectric Generator with Piled Conical Rings Structure: *Tsutomu Kanno*¹; Akihiro Sakai¹; Kouhei Takahashi¹; Atsushi Omote¹; Hideaki Adachi¹; Yuka Yamada¹; ¹Panasonic Corporation

1:50 PM I2, Late News

2:10 PM

I3, Thermoelectric Properties of $ErSb_xIn_{1-x}Sb$ Thin Films Grown by MBE: *Hong Lu*¹; Peter Burke¹; Nathan Hackman¹; John Bowers¹; Arthur Gossard¹; ¹UCSB

2:30 PM Student

I4, Nanoparticle Size Dependence of the Electrical, Thermal, and Optical Properties of Er-Doped $In_{0.53}Ga_{0.47}As$: *Peter Burke*¹; John Bowers¹; Arthur Gossard¹; ¹University of California, Santa Barbara

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2:50 PM Student

I5, Improving Thermoelectric Power Generation Efficiency with Epitaxial TbAs/III-V Nanocomposites: *Laura Cassels¹; Ashok Ramu²; Gilles Pernot³; Trevor Buehl²; Peter Burke²; Art Gossard²; Chris Palmström²; John Bowers²; Ali Shakouri³; Joshua Zide¹; ¹University of Delaware; ²University of California, Santa Barbara; ³University of California, Santa Cruz*

3:10 PM Break

3:30 PM Student

I6, The MOCVD Growth of Erbium Antimonide Nanocomposite Embedded III-V Host Materials and Characterization for Thermoelectrics: *Takehiro Onishi¹; Tela Favalaro¹; Ali Shakouri¹; Elane Coleman²; Gary Tompa²; Nobuhiko Kobayashi¹; ¹UCSC; ²Structured Materials Industries, Inc.*

3:50 PM Student

I7, Cross-Plane Transport Properties of p-Type La_{0.67}Sr_{0.33}MnO₃/LaMnO₃ Perovskite Oxide Metal/Semiconductor Superlattices: *Pankaj Jha¹; Timothy D. Sands²; Laura Cassels³; Tela Favalaro⁴; Benjamin Kirk³; Philip Jackson⁴; Polina Burmistrova¹; Xianfan Xu⁵; Joshua Zide³; Ali Shakouri⁴; ¹Electrical and Computer Engineering and Birck Nanotechnology Center, Purdue University; ²ECE,MSE and Birck Nanotechnology Center, Purdue University; ³Material Science and Engineering, University of Delaware; ⁴Electrical Engineering, University of California, Santa Cruz; ⁵Mechanical Engineering and Birck Nanotechnology Center, Purdue University*

4:10 PM

I8, Temperature-Dependent Thermal Properties of HgCdTe Superlattices: *Kejia Zhang¹; Abhishek Yadav¹; Lei Shao¹; Ramana Bommena²; Jun Zhao²; Silviu Velicu²; Kevin Pipe¹; ¹University of Michigan; ²EPIR Technologies, Inc.*

4:30 PM Student

I9, Development of III-Nitride Materials for Thermoelectric Applications: *Alexander Steinhilber¹; John Haberstroh¹; Hiroaki Ohta¹; Steven Denbaars¹; John Bowers¹; Shuji Nakamura¹; ¹UCSB*

4:50 PM Student

I10, Highly Ordered Vertical Silicon Nanowire Arrays Embedded in Polymer for Thin-Film Thermoelectric Devices: *Benjamin Curtin¹; John Bowers¹; ¹Department of Electrical and Computer Engineering, University of California, Santa Barbara*

Session J: Nanowire Transport and Devices

Wednesday PM Room: Lotte Lehmann
June 22, 2011 Location: University of California-Santa Barbara

Session Chairs: David Janes, Purdue University; Raymond Tsui, Motorola Laboratories

1:30 PM

J1, Molecular Surface Passivation Effects on Indium Oxide Nanowire Transistors: *Seongmin Kim¹; Patrick Carpenter¹; Rand Jean¹; Sanghyun Ju²; David Janes¹; ¹Purdue University; ²Kyonggi University*

1:50 PM Student

J2, Electrically Pumped ZnO Nanowire p-n Junction Laser: *Sheng Chu¹; Guoping Wang¹; Jianze Zhao¹; Jieying Kong¹; Lin Li¹; Jingjian Ren¹; Jianlin Liu¹; ¹University of California Riverside*

2:10 PM Student

J3, Electrical Transport Study of Schottky Barrier Based ZnO Nanowire FETs: *Ye Shao¹; Jongwon Yoon²; Hyeonnam Kim¹; Venkatesh Balasubramanian¹; Takhee Lee²; Jae-Hyung Jang²; Wu Lu¹; ¹Ohio State University; ²Gwangju Institute of Science and Technology*

2:30 PM Student

J4, ZnO Nanowire-Based Field Effect Transistors with Non-Volatile Memory Function Using Mobile Protons: *Jongwon Yoon¹; Woong-Ki Hong²; Minseok Jo¹; Gunho Jo¹; Minhyeok Choe¹; Woojin Park¹; Jung Inn Sohn²; Hyunsang Hwang¹; Mark Welland²; Takhee Lee¹; ¹Gwangju Institute of Science and Technology; ²Nanoscience Centre*

2:50 PM

J5, Raman and Electrical Probes of Carrier Concentration in Si-Doped GaN Nanowires Grown by Plasma-Assisted MBE: *Lawrence Robins¹; Norman Sanford¹; John Schlager¹; Kris Bertness¹; Paul Blanchard¹; ¹NIST*

3:10 PM Break

3:30 PM Student

J6, Electrodeposited InSb Nanowires: Structural Properties and Transistor Performance: *Suprem Das¹; Collin Delker¹; Dmitri Zakharov¹; Yong Chen¹; Timothy Sands¹; David Janes¹; ¹Purdue University*

3:50 PM Student

J7, Electron Transport in One-Dimensional InAs Nanowire Transistors: *Hanshuang Liang¹; Ganesh Subramanian¹; Hao Wu¹; Hongbin Yu¹; Ping-Show Wang²; Joshua Shapiro²; Diana Huffaker²; ¹Arizona State University; ²University of California at Los Angeles*

4:10 PM

J8, Electrical Properties of Axial and Radial Nanowire pn-Junctions – A Comparison: *Christoph Gutsche¹; Andrey Lysov¹; Ingo Regolin¹; Werner Prost¹; Franz-Josef Tegude¹; ¹University of Duisburg-Essen*

4:30 PM Student

J9, GaAs Core-Shell Nanowire-Based Vertical p-n Diodes: *Hao Wu¹; Hanshuang Liang¹; Hongbin Yu¹; Joshua Shapiro²; Ping-Show Wong²; Diana Huffaker²; ¹Arizona State University; ²University of California at Los Angeles*

4:50 PM Student

J10, Role of Defect States in Charge Transport in Semiconductor Nanowires: *Dongkyun Ko¹; Xianwei Zhao¹; Kongara Reddy¹; Oscar Restrepo¹; Wolfgang Windl¹; Nitin Padture¹; Nandini Trivedi¹; Fengyuan Yang¹; Ezekiel Johnston-Halperin¹; ¹The Ohio State University*

Session K:

Silicon Carbide Growth, Characterization and Devices

Wednesday PM Room: Multicultural Center Lounge
June 22, 2011 Location: University of California-Santa Barbara

Session Chairs: Joshua Caldwell, Naval Research Laboratory; Robert Stahlbush, Naval Research Laboratory

1:30 PM Invited

K1, The Evolution of the SiC Power MOSFET from Lab Demonstration to Commercial Product: *Brett Hull¹; Jon Zhang¹; Mrinal Das¹; Sei-Hyung Ryu¹; Michael O'Loughlin¹; Al Burk¹; Anant Agarwal¹; John Palmour¹; ¹Cree, Inc.*

2:10 PM

K2, A Bondable Metallization Stack that Prevents Diffusion of Oxygen and Gold into Monolithically Integrated Circuits Operating above 500 °C: *David Spry¹; Dorothy Lukco²; ¹NASA Glenn; ²ASRC*

2:30 PM

K3, High-Low Temperature Performance of 20 A, 1200 - 1700 V 4H-SiC Power MOSFETs: *Lin Cheng¹; Anant Agarwal¹; Sarit Dhar¹; Sei-Hyung Ryu¹; Brett Hull¹; John Palmour¹; ¹Cree, Inc.*

2:50 PM Student

K4, Improved Microstructure and Ohmic Contact of Nb Electrode on N-Type 4H-SiC: *Kunhwa Jung¹; Yuji Sutou¹; Junichi Koike¹; ¹Tohoku Univ.*

3:10 PM Break

3:30 PM

K5, Slow Thermal Emission from Traps in 4H-SiC Epilayers: *Paul Klein*¹; Amitesh Shrivastava²; Tangali Sudarshan²; ¹Naval Research Laboratory; ²University of South Carolina

3:50 PM Student

K6, Deflection of Threading Dislocations with Burgers Vector $c/c+a$ Observed in 4H-SiC Substrates and Axial Slices with Associated Stacking Faults: *S. Byrappa*¹; F. Wu¹; H. Wang¹; B. Raghathamachar¹; G. Choi¹; S. Sun¹; M. Dudley¹; E.K. Sanchez¹; D. Hansen¹; R. Drachev¹; S.G. Mueller¹; M.J. Laboda¹; ¹Stony Brook University

4:10 PM

K7, Stacking Faults Originating from BPDs in High-Doped Buffer Layers: *Nadeemullah Mahadik*¹; Robert Stahlbush¹; Eugene Imhoff¹; Karl Hobart¹; Rachael Myers-Ward¹; Charles Eddy Jr.¹; D. Gaskill¹; Fritz Kub¹; ¹Naval Research Laboratory

4:30 PM Student

K8, Step Controlled Epitaxy on 4° and 1° Off-Cut 4H and 6H-SiC Substrate Using Dichlorosilane: *Sabih Omar*¹; Haizheng Song¹; Iftekhar Chowdhury¹; MVS Chandrashekar¹; Tangali Sudarshan¹; ¹University of South Carolina

4:50 PM Student

K9, Defect Structures of $B_{12}As_2$ Single Crystalline Epitaxial Layers on Off-Axis (0001) 4H-SiC Substrates: *Yu Zhang*¹; Hui Chen¹; Michael Dudley¹; Yi Zhang²; James Edgar²; Yinyan Gong³; Silvia Bakalova³; Martin Kuball³; Lihua Zhang⁴; Dong Su⁴; Yimei Zhu⁴; ¹Stony Brook University; ²Kansas State University; ³University of Bristol; ⁴Brookhaven National Laboratory

Session L:

Graphene Fabrication and Devices

Wednesday PM Room: Multicultural Center Theatre
June 22, 2011 Location: University of California-Santa Barbara

Session Chairs: Debdeep Jena, University of Notre Dame; Avik Ghosh, University of Virginia

1:30 PM Invited

L1, Single-Layer MoS₂ Transistors: Branimir Radisavljevic¹; Aleksandra Radenovic¹; Jacopo Brivio¹; *Andras Kis*¹; ¹EPFL

2:10 PM

L2, Role of Optical Phonon in Graphene Nanoribbon Tunnel Transistors: Strategy for Abrupt Switching from Material's Point of View: *Youngki Yoon*¹; Sayeef Salahuddin¹; ¹University of California - Berkeley

2:30 PM

L3, Fabrication of Top-Gated Sub-10 nm Epitaxial Graphene Nanoribbon FETs Using Hydrogen Silsesquioxane(HSQ): *W. S. Hwang*¹; K. Tahy¹; J. L. Tedesco²; R. L. Myers-Ward²; P. M. Campbell²; C. R. Eddy Jr.²; D. K. Gaskill²; H. Xing¹; A. C. Seabaugh¹; D. Jena¹; ¹University of Notre Dame; ²U. S. Naval Research Laboratory

2:50 PM Student

L4, Semiconducting Graphene: Prospects and Challenges: *Frank Tseng*¹; Avik Ghosh¹; ¹University of Virginia

3:10 PM Break

3:30 PM

L5, Influence of Trapped Single Charges in Single Walled Carbon Nanotube Transistor with SiN_x/Al₂O₃ Double Wrapped Layers: *Takafumi Kamimura*¹; Kazuhiko Matsumoto²; ¹National Institute of Advanced Industrial Science and Technology; ²Osaka University

3:50 PM

L6, Deposition and Characterization of AlN Dielectric Films on Graphene: *Mark Fanton*¹; Joshua Robinson¹; David Rearick¹; Michael LaBella¹; Kathleen Trumbull¹; Randal Cavalero¹; Matthew Hollander¹; Zachery Hughes¹; David Snyder¹; ¹Penn State University

4:10 PM Student

L7, Graphene as a Heat-Spreading Layer in Blue LEDs: *Chongmin Lee*¹; ¹Korea University

4:30 PM

L8, RCA Clean Assisted Transfer of CVD Grown Graphene: *Xuelei Liang*¹; Brent Sperling¹; Irene Calizo¹; Guangjun Cheng¹; Christina Hacker¹; Qin Zhang¹; Yaw Obeng¹; Kai Yan²; Hailin Peng²; Qiliang Li³; Xiaoxiao Zhu³; Curt Richter¹; ¹National Institute of Standards and Technology; ²College of Chemistry and Molecular Engineering; ³Department of Electrical and Computer Engineering

4:50 PM Student

L9, Electrical Property and Photoconductivity of Highly Dense and Vertically Aligned ZnO Nanowires Using Graphene as Electrodes: *Jian Lin*¹; Jiebin Zhong¹; Miroslav Penchev¹; Mihri Ozkan¹; Cengiz Ozkan¹; ¹University of California Riverside

Session M: III-Nitrides: Defects and LEDs

Wednesday PM Room: Santa Barbara Harbor
June 22, 2011 Location: University of California-Santa Barbara

Session Chairs: Andrew Allerman, Sandia National Laboratories; Russell Dupuis, Georgia Institute of Technology

1:30 PM

M1, A Defect-Based Mechanism for Efficiency Droop in Nitride Light Emitting Diodes: *Normand Modine*¹; Andrew Armstrong¹; Mary Crawford¹; Weng Chow¹; ¹Sandia National Laboratories

1:50 PM

M2, Impact of Extended and Point Defects on InGaN LED Efficiency: *Andrew Armstrong*¹; Tania Henry¹; Daniel Koleske¹; Mary Crawford¹; ¹Sandia National Laboratories

2:10 PM Student

M3, Effect of In_xAl_{1-x}N Electron Blocking Layer on Quantum Efficiency in Visible Light-Emitting Diodes Grown by Metalorganic Chemical Vapor Deposition: *Suk Choi*¹; Mi-Hee Ji¹; Jeomoh Kim¹; Hee Jin Kim¹; Jae-Hyun Ryou¹; P. Douglas Yoder¹; Russell Dupuis¹; Kewei Sun²; Alec Fischer²; Fernando Ponce²; ¹Georgia Institute of Technology; ²Arizona State University

2:30 PM Student

M4, Semipolar AlGaN Buffers for Deep Ultraviolet Diode Lasers: *Roy Chung*¹; Erin Young¹; Dan Haeger¹; Steven DenBaars¹; James Speck¹; Dan Cohen¹; ¹University of California Santa Barbara

2:50 PM

M5, Low Dislocation Density Al_{0.32}Ga_{0.68}N by Overgrowth of Patterned Templates: *Andrew Allerman*¹; Mary Crawford¹; Stephen Lee¹; Karen Cross¹; Mary Miller¹; Jonathan Wierer¹; Blythe Clark¹; ¹Sandia National Laboratories

3:10 PM Break

3:30 PM Student

M6, Enhancement of Hole Transport and Carrier Distribution in InGaN/GaN Multiple Quantum Wells by Controlling Indium Content of p-Type Layer in Visible Light-Emitting Diodes: *Jeomoh Kim*¹; Mi-Hee Ji¹; Suk Choi¹; Jae-Hyun Ryou¹; Russell Dupuis¹; Kewei Sun²; Reid K. Juday²; Alec M. Fischer²; Fernando A. Ponce²; ¹Georgia Institute of Technology; ²Arizona State University

3:50 PM

M7, P-Side-Down, Ga-Polar, Green-Emitting Single Heterostructure LEDs: *Scott Newman*¹; Jonathan Wright¹; Chad Gallinat¹; Ryan Enck¹; Anand Sampath¹; Hongen Shen¹; Meredith Reed¹; Michael Wraback¹; ¹US Army Research Laboratory

4:10 PM

M8, Characterization of Green Semi-Polar (10-11) GaInN/GaN Light Emitting Diodes: *Christoph Stark*¹; Shi You¹; Liang Zhao¹; Theeradetch Detchprohm¹; Christian Wetzel¹; Edward Preble²; Tanya Paskova²; ¹Rensselaer Polytechnic Institute; ²Kyma Technologies, Inc.

4:30 PM

M9, Optical Properties of Molecular Beam Epitaxy Grown High in Content (~20%) InGaN film Emitting in Green (540 nm): *Vladimir Protasenko*¹; Jai Verma¹; Guowang Li¹; HuiLi (Grace) Xing¹; Debdeep Jena¹; ¹University of Notre Dame

4:50 PM Student

M10, Effects of Dislocations on Luminescence in *m*-Plane InGaN Quantum Wells: *Yu Huang*¹; Kewei Sun¹; Alec Fischer¹; Qiyuan Wei¹; Reid Juday¹; Fernando Ponce¹; R. Kato²; Toshiya Yokogawa²; ¹Arizona State University; ²Panasonic Corporation

Session N:

Next Generation Solar Cell Materials and Devices

Wednesday PM
June 22, 2011

Room: State Street
Location: University of California-Santa Barbara

Session Chairs: Christian Wetzel, Rensselaer Polytechnic Institute; Mark Goorsky, University of California, Los Angeles

1:30 PM

N1, Preparation of the Red Phosphor Nanoparticle Films for the Application to Silicon Solar Cells: *Masakazu Kobayashi*¹; Ayaka Yagi¹; Miwa Inaguma¹; Sayako Hamaguchi¹; ¹Waseda University

1:50 PM Student

N2, GaAs Nanopillar Photovoltaics Based on Catalyst-Free Patterned Growth: *Giacomo Mariani*¹; Ping-Show Wong¹; Joshua Shapiro¹; Diana Huffaker¹; ¹University of California, Los Angeles

2:10 PM Student

N3, Wafer Bonded GaAs-Sapphire for Photovoltaic Applications via Adhesive Bonding: *Nikholas Toledo*¹; Carl Neufeld¹; Michael Scarpulla²; Trevor Buehl²; Samantha Cruz²; Arthur Gossard²; Steven Denbaars²; James Speck²; Umesh Mishra¹; ¹Department of Electrical and Computer Engineering, University of California, Santa Barbara; ²Materials Department, University of California, Santa Barbara

2:30 PM

N4, Thin Film III-V Photovoltaics on Flexible Metal Substrates and Defect Mitigation Strategies: *Venkat Selvamani*¹; Senthil Sambandam²; Aarthi Sundaram¹; Akhil Mehrotra¹; Alex Freundlich¹; ¹University of Houston; ²SuperPower

2:50 PM N5, Late News

3:10 PM Break

3:30 PM

N6, Towards >15% Solar Cells on Metal Foils: Heteroepitaxial Crystal Silicon on Alumina: *Charles Teplin*¹; M. Parans Paranthaman²; Thomas Fanning³; Kirstin Alberi¹; Lee Heatherly²; Kyunghoon Kim²; Frederick List²; Jon Bornstein²; Claudia Cantoni²; Paul Schroeter³; David Young¹; Howard Branz¹; ¹National Renewable Energy Lab; ²ORNL; ³Ampulse

3:50 PM Student

N7, High External Quantum Efficiency and Fill-Factor InGaN-Based Solar Cells Grown by NH₃-MBE: *Jordan Lang*¹; Carl Neufeld¹; Christophe Hurni¹; Samantha Cruz¹; Elison Matioli¹; Umesh Mishra¹; James Speck¹; ¹University of California, Santa Barbara

4:10 PM Student

N8, Design Principles for Light-Trapping in Thin Silicon Films with Embedded Dielectric Nanoparticles: *James Nagel*¹; Michael Scarpulla¹; ¹University of Utah

4:30 PM Student

N9, Single Crystalline Si Substrate Growth by Lateral Diffusion LPE Technology for PV Applications: *Li Bo*¹; Adrian Kitai¹; Huaxiang Shen¹; ¹McMaster University

4:50 PM N10, Late News

Technical Program

Session O: III-Nitrides: UV Emitters and Detectors

Thursday AM Room: Corwin East
June 23, 2011 Location: University of California-Santa Barbara

Session Chairs: Michael Wraback, US Army Research Lab; Zlato Sitar, North Carolina State University

8:20 AM

O1, Fabrication of UV Emitting Devices Using Vertical ZnO Nanorod Arrays on the p-GaN Films: *Shrawan Jha*¹; Oleksandr Kutsay¹; Igor Bello¹; Shuit-Tong Lee¹; ¹City University of Hong Kong

8:40 AM

O2, Low-Threshold ZnO Random Laser Diode Realized by Double Heterojunction Structure: *Jieying Kong*¹; Sheng Chu¹; Zheng Zuo¹; Jingjian Ren¹; Mario Olmedo¹; Jianlin Liu¹; ¹University of California, Riverside

9:00 AM Student

O3, ZnMgO-Based Photodetectors for Short Wavelength and Light Polarization Detection: *Gema Tabares*¹; Adrián Hierro¹; Christiane Deparis²; Christian Morhain²; Jean-Michel Chauveau²; ¹ISOM-Dept. Ingenieria Electrica, Universidad Politecnica de Madrid; ²CNRS-CRHEA

9:20 AM

O4, Fabrication and Characterization of 265 nm Light Emitting Diodes on AlN Single Crystal Substrates: *Ramón Collazo*¹; Seiji Mita²; Jinqiao Xie²; Anthony Rice¹; James Tweedie¹; Rafael Dalmau²; Baxter Moody²; Raoul Schlessler²; Ronny Kirste³; Axel Hoffmann³; Zlatko Sitar¹; ¹North Carolina State University; ²HexaTech, Inc.; ³Technical University Berlin

9:40 AM

O5, Time-Resolved Photoluminescence of AlInN/AlN Multiple Quantum Well Active Regions for Mid-UV Emitters: *Gregory Garrett*¹; Hongen Shen¹; Michael Wraback¹; Hee Jin Kim²; Zachary Lochner²; Jae-Hyun Ryou²; Russell Dupuis²; ¹US Army Research Laboratory; ²Georgia Institute of Technology

10:00 AM Break

10:20 AM Student

O6, Enhanced Inter-Band Tunneling by Polarization Engineering in InGaN/GaN Quantum Wells: *Sriram Krishnamoorthy*¹; Aaron Arehart¹; Digbijoy Nath¹; Fatih Akyol¹; Pil Sung Park¹; Michele Esposto¹; Steve Ringel¹; Siddharth Rajan¹; ¹The Ohio State University

10:40 AM

O7, Effects of Polarization Interface Charge on GaN/SiC Separate Absorption and Multiplication Avalanche Photodiodes: *Chad Gallinat*¹; Anand Sampath; Ryan Enck¹; Paul Rotella¹; Paul Shen¹; Michael Wraback¹; Qiugui Zhou²; Dion McIntosh²; Joe Campbell²; ¹Army Research Lab; ²University of Virginia

11:00 AM

O8, Low-Temperature Growth and Characterization of p-GaN and Graded p-InGaN Layers by MOCVD for Photovoltaic Applications: *Matthew Laurent*¹; Ajay Raman¹; Daniel Denninghoff¹; Stacia Keller¹; Umesh Mishra¹; ¹UC Santa Barbara

11:20 AM Student

O9, Carrier Lifetimes and Recombination Phenomena in InGaN/ GaN Quantum Dot and Quantum Well LEDs: A Comparative Study: *Animesh Banerjee*¹; Meng Zhang¹; Boon Ooi²; Pallab Bhattacharya¹; ¹University of Michigan; ²KAUST

11:40 AM

O10, Characterization of Ultraviolet LEDs by Electrical Analysis and Laser-Based Failure Analysis Techniques: *Mary Miller*¹; Edward Cole Jr.¹; Paiboon Tangyungong¹; ¹Sandia National Laboratories

Session P: Oxide Semiconductor Devices

Thursday AM Room: Corwin West
June 23, 2011 Location: University of California-Santa Barbara

Session Chairs: Jamie Phillips, University of Michigan; Holger von Wenckstern, Universität Leipzig

8:20 AM Invited

P1, Memristance and Current-Driven Phase Transition in Multifunctional Binary Oxide Nanodevices: *Matthew Pickett*¹; Julien Borghetti¹; J. Joshua Yang¹; Gilberto Medeiros-Ribeiro¹; R. Stanley Williams¹; ¹Hewlett-Packard Laboratories

9:00 AM

P2, Switching Characteristics and Mechanism of Nano-Scale Memristors Based on Epitaxial ZnO Nano-Islands: *Jing Qi*¹; Mario Olmedo¹; Jingjian Ren¹; Ning Zhan¹; Jianze Zhao¹; Jianlin Liu¹; ¹University of California, Riverside

9:20 AM Student

P3, Investigation of Multi-Barrier ZnO-Schottky Contacts: *Stefan Müller*¹; Holger von Wenckstern¹; Jörg Lenzner¹; Otwin Breitenstein²; Marius Grundmann¹; ¹Universität Leipzig; ²Max-Planck-Institut für Mikrostrukturphysik

9:40 AM Student

P4, Interface Charge Characteristics of HfO₂/ZnO Thin Films: *Jeffrey Siddiqui*¹; Jamie Phillips¹; Burhan Bayraktaroglu²; Kevin Leedy²; ¹University of Michigan; ²AFRL Wright-Patterson

10:00 AM Break

10:20 AM Student

P5, Low-Temperature Processed Schottky-Gated Field-Effect Transistors Based on Amorphous Gallium-Indium-Zinc-Oxide: *Michael Lorenz*¹; Alexander Lajn¹; Heiko Frenzel¹; Holger von Wenckstern¹; Marius Grundmann¹; Pedro Barquinha²; Elvira Fortunato²; Rodrigo Martins²; ¹University of Leipzig; ²CENIMAT, I3N, FCT-UNL

10:40 AM Student

P6, High Pressure Hydrogen Annealing of Indium-Gallium-Zinc Oxide Thin Film Transistors: *Se-I Oh*¹; Jae-Hyung Jang¹; Dae-Seok Lee¹; Hyunsang Hwang¹; ¹GIST

11:00 AM Student

P7, The Effect of Ga Doping on Bias Stress Stability of ZnO TFT: *Chieh-Jen Ku*¹; Ziqing Duan¹; Yicheng Lu¹; ¹Rutgers University

11:20 AM

P8, Electrically Stable Amorphous InGaZnO Thin-Film Transistors and High-Gain Inverters: *Jungbae Kim*¹; Canek Fuentes-Hernandez¹; Do Kyung Hwang¹; Hyeunseok Cheun¹; Shree Tiwari¹; Bernard Kippelen¹; ¹Georgia Institute of Technology

11:40 AM Student

P9, Growth and Investigation of Hexagonal Zinc Oxide Microdisk Resonators: *Kathryn Greenberg*¹; John Joo¹; Evelyn Hu¹; ¹Harvard University

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Session Q: III-Nitrides: Electronics II

Thursday AM
June 23, 2011

Room: Flying A
Location: University of California-Santa Barbara

Session Chairs: Russell Dupuis, Georgia Institute of Technology; Huili Grace Xing, University of Notre Dame

8:20 AM Student

Q1, ALD Al_2O_3 Thickness-Dependent Study of AlN/GaN MOS-HEMTs: *Satyaki Ganguly*¹; Jai Verma¹; Guowang Li¹; Huili Xing¹; Debdeep Jena¹; ¹University of Notre Dame

8:40 AM Student

Q2, Al_2O_3 Based Etch-Stop Technology for the Gate Recess in N-Polar AlGaIn/GaN MIS-HEMTs with Si_3N_4 Passivation: *Seshadri Kolluri*¹; David Brown¹; Andrew Carter¹; Stacia Keller¹; Steven DenBaars¹; Umesh Mishra¹; ¹University of California, Santa Barbara

9:00 AM Student

Q3, MBE Regrown Ohmic Contacts with Rc of 0.15 ohm-mm in InAlN/GaN High Electron Mobility Transistor: *Jia Guo*¹; Jai Verma¹; Yu Cao¹; Xiang Gao²; Shiping Guo²; Ed Beam³; Andrew Ketterson³; Michael Schuette³; Paul Saunier³; Mark Wistey¹; Debdeep Jena¹; Huili (Grace) Xing¹; ¹University of Notre Dame; ²IQE RF LLC; ³Triquint Semiconductor

9:20 AM

Q4, Pre- and Post-Treatment Investigations of Al Oxide by Atomic Layer Deposition in Schottky Metal/Al Oxide/AlGaIn/GaN MOS Diodes: *Hyeonnam Kim*¹; Wu Lu¹; ¹The Ohio State University

9:40 AM

Q5, GaN/Diamond AlGaIn/GaN/AlGaIn DH-HEMT Produced by Epi-Inverted Wafer Processing: *Edwin Piner*¹; John Roberts²; ¹Texas State University; ²Nitronex Corporation

10:00 AM Break

10:20 AM

Q6, Al_xIn_{1-x}N/GaN Heterostructures Grown by MEMOCVD: *Daniel Billingsley*¹; Ajay Sattu¹; Xuhong Hu¹; Jianyu Deng¹; Grigory Simin¹; Max Shatalov¹; Michael Shur¹; Jinwei Yang¹; Remis Gaska¹; ¹Sensor Electronic Technology

10:40 AM Student

Q7, Lateral Confinement of Electrons and Quasi-1D Channels Based Devices: *Digbijoy Nath*¹; Pil Sung Park¹; Michele Esposito¹; David Brown²; Stacia Keller²; Umesh Mishra²; Siddharth Rajan¹; ¹The Ohio State University; ²UC Santa Barbara

11:00 AM

Q8, Polarization-Engineered GaN-Based Heterostructure for Normally-off High-Electron Mobility Transistors: *Hyeonnam Kim*¹; Digbijoy Nath¹; Siddharth Rajan¹; Wu Lu¹; ¹The Ohio State University

11:20 AM

Q9, Tunneling Current via Dislocations in AlGaIn/GaN Schottky Contacts: *Peter Kordos*¹; Jaroslav Kovac¹; Roman Sramaty¹; Jaroslava Skriniarova¹; Alexander Satka¹; Ales Chvala¹; Daniel Donoval¹; ¹Department of Microelectronics

11:40 AM Student

Q10, Growth Studies on Quaternary AlInGaIn Layers for HEMT Application: *Benjamin Reuters*¹; ¹RWTH GaN Device Technology

Session R: Narrow Bandgap Materials and Devices

Thursday AM
June 23, 2011

Room: Lobero
Location: University of California-Santa Barbara

Session Chairs: Ganesh Balakrishnan, University of New Mexico; L. Ralph Dawson, University of New Mexico

8:20 AM Student

R1, Improved Performance of Long-Wave Infrared InAs/GaSb Strained Layer Superlattices Detectors by Novel ZnTe Passivation: *Maya Narayanan Kutty*¹; Elena Plis¹; Svyatoslav Smolev¹; Nutan Gautam¹; Mikhail Naydenkov¹; Stephen Myers¹; Ralph Dawson¹; Weiming Wang²; Jamie Phillips²; Sanjay Krishna¹; ¹University of New Mexico; ²The University of Michigan

8:40 AM

R2, Strain-Engineered Binary and Ternary Type-II Superlattice Structures and Photodiodes Grown by Metalorganic Chemical Vapor Deposition: *Yong Huang*¹; *Jae-Hyun Ryou*¹; Russell Dupuis¹; Elizabeth Steenbergen²; Jin Fan²; Yong-Hang Zhang²; Daniel Zuo³; Ben Kesler³; Adam Petschke³; Martin Mandl³; Shun-Lien Chuang³; Hefei Hu³; Kyohyun Kim³; Yen-Ting Lu³; Jian-Min Zuo³; ¹Georgia Institute of Technology, Atlanta, GA, USA; ²Arizona State University; ³University of Illinois at Urbana-Champaign

9:00 AM Student

R3, Study of Minority Carrier Lifetime and Background Carrier Concentration in GaSb-InAs Strained-Layer Superlattices and Bulk Epitaxial Layers by Optical Modulation Response: *Ding Wang*¹; Dmitri Donetsky¹; Stefan Svensson²; Sergei Suchalkin¹; Gregory Belenky¹; Amy Liu³; Joel Fastenau³; Dmitri Lubyshev³; ¹Stony Brook University; ²US Army Research Laboratory; ³IQE, Inc

9:20 AM Student

R4, Increased Thermophotovoltaic Efficiencies Using a Two Dimensional Photonic Crystal Cavity: *Corey Shemelya*¹; Dante Demeo¹; Thomas Vandervele¹; ¹Tufts University

9:40 AM

R5, Effect of Dislocation Density on Thermal Boundary Conductance across GaSb/GaAs Interfaces: *Patrick Hopkins*¹; John Duda¹; Leslie Phinney¹; Stephen Clark²; Christopher Hains²; Thomas Rotter²; Ganesh Balakrishnan²; ¹Sandia National Laboratories; ²University of New Mexico

10:00 AM Break

10:20 AM Student

R6, Low Field Electron Transport in Mixed Arsenide Antimonide Quantum-Well Heterostructures: *Ashish Agrawal*¹; Ashkar Ali¹; Rajiv Misra¹; Peter Schiffer¹; Brad Boos²; Brian Bennett²; Suman Datta¹; ¹The Pennsylvania State University; ²Naval Research Lab

10:40 AM Student

R7, AlGaSb/InAs-Based Staggered Heterojunction Tunnel Diodes: *Siyuan Gu*¹; Gerry Sullivan²; Lingquan Wang³; Peter Asbeck¹; ¹University of California San Diego; ²Teledyne Scientific Company; ³Global Foundries

11:00 AM Student

R8, Growth and Characterization of AlInSb Metamorphic Buffers on GaSb and GaAs Substrates for the Growth of MWIR Lasers: *Stephen Clark*¹; P. Ahiwar¹; V. Patel¹; S. Reissmann¹; T. Rotter¹; A. Albrecht¹; H. Xu¹; C. Hains¹; L. Dawson¹; Y. Picard¹; G. Balakrishnan¹; ¹CHTM; ²Carnegie Mellon University

Technical Program

11:20 AM

R9, Optimization of MBE Growth for the Development of Mid-IR II-VI Quantum Cascade Lasers: *Richard Moug*¹; Humara Sultana¹; Yu Yao²; Adrian Alfaro-Mantinez¹; Le Peng¹; Thor Garcia¹; Aidong Shen¹; Claire Gmachl¹; Maria Tamargo²; ¹City College New York; ²Princeton University

11:40 AM Student

R10, Growth of III-Sb VECSELS for High-Power Continuous Wave Operation: *P. Ahirwar*¹; Thomas Rotter¹; Alexander Albrecht¹; Stephen Clark¹; Victor Patel¹; Simon Reissmann¹; Huiwen Xu¹; Christopher Hains¹; Larry Dawson¹; Ganesh Balakrishnan¹; Jorg Hader²; Jerome Moloney²; ¹Center for High Technology Materials; ²University of Arizona

Session S: Nanowire Synthesis and Characterization

Thursday AM Room: Lotte Lehmann
June 23, 2011 Location: University of California-Santa Barbara

Session Chairs: Chen Yang, Purdue University; Kris Bertness, National Institute of Standards and Technology

8:20 AM Student

S1, Photoluminescence of Chemical Vapor Deposition-Grown Diamond Nanowires: *Steven Palefsky*¹; Chih-Hsun Hsu¹; Sylvain Cloutier²; Jimmy Xu¹; ¹Brown University; ²University of Delaware

8:40 AM Student

S2, Properties of ErAs and ErSb Nanorods Embedded in High-Index III-V Semiconductors: *Trevor Buehl*¹; Christopher Palmstrøm¹; Arthur Gossard¹; ¹UCSB

9:00 AM Student

S3, Dynamic Control of Growth Kinetics for Three-Dimensional Semiconductor Nano-Heterostructures: *Santino Carnevale*¹; Jing Yang¹; Patrick Phillips¹; Michael Mills¹; Roberto Myers¹; ¹Ohio State University

9:20 AM Student

S4, Structural Characterization of InGaAs Axial Inserts in GaAs Catalyst-Free Nanopillars Grown by Selective-Area MOCVD: *Joshua Shapiro*¹; Diana Huffaker¹; ¹UCLA

9:40 AM

S5, Control of III-V Nanowire Epitaxy by Precursor Chemistry: Omid Salehzadeh¹; *Simon Watkins*¹; ¹Simon Fraser University

10:00 AM Break

10:20 AM Student

S6, Temperature-Dependent Growth Direction of Epitaxial InSb Nanowires by Chemical Vapor Deposition: *Jiebin Zhong*¹; Jian Lin¹; Miroslav Penchev¹; Maziar Ghazinejad¹; Mihri Ozkan¹; Cengiz Ozkan¹; ¹University of California Riverside

10:40 AM Student

S7, Effect of Precursor Flow Rates on the Growth of InPsb Nanowires on InP(111)B: Chilan Ngo¹; Marta Pozuelo¹; Matthew Mecklenburg²; Hailong Zhou³; Chris Regan²; Robert Hicks³; *Suneel Kodambaka*¹; ¹UCLA Department of Materials Science; ²UCLA Department of Physics and Astronomy; ³UCLA Department of Chemical and Biomolecular Engineering

11:00 AM

S8, Precise Placement and Diameter Control of Catalyst-Free Molecular Beam Epitaxy Grown GaN Nanowires: *Aric Sanders*¹; Kris Bertness¹; Andrew Herrero¹; Alexana Roshko¹; Norman Sanford¹; John Schlager¹; Todd Harvey¹; Devin Rourke¹; ¹National Institute of Standards and Technology (NIST)

11:20 AM Student

S9, Synthesis and Fabrication of ZnTe Nanosheet Field Effect Transistors for Photonic Applications: *Ebraheem Azhar*¹; Jih-Hong Peng¹; Ganesh Subramanian¹; Sandwip Dey¹; Hongbin Yu¹; ¹Arizona State University

11:40 AM S10, Late News

Session T: Growth of Graphene and Carbon Nanotubes

Thursday AM Room: Multicultural Center Theatre
June 23, 2011 Location: University of California-Santa Barbara

Session Chairs: Mike Spencer, Cornell University; Randall Feenstra, Carnegie Mellon University

8:20 AM Student

T1, Epitaxial Graphene Formation on Step-Free 4H-SiC(0001): *Michael Bolen*¹; Bob Colby¹; Eric Stach²; Michael Capano¹; ¹Purdue University; ²Brookhaven National Laboratory

9:00 AM

T2, Effects of Substrate Orientation and Growth Environment on the Structural and Electronic Properties of Epitaxial Graphene on SiC(0001): Joshua Robinson¹; Kathleen Trumbull¹; Michael LaBella¹; Randall Cavalero¹; Matthew Hollander¹; Michael Zhu¹; Maxwell Wetherington¹; *Mark Fanton*¹; David Snyder¹; ¹Penn State University

9:20 AM

T3, High Mobility Epitaxial Graphene on Sapphire via Metal-Free CVD: *Mark Fanton*¹; Joshua Robinson¹; Conor Puls¹; Brian Weiland¹; Michael LaBella¹; Kathleen Trumbull¹; Richard Kasarda¹; Casey Howsare¹; Joseph Stitt¹; David Snyder¹; ¹Penn State University

9:40 AM Student

T4, Study of Epitaxial Graphene on Non-Polar 6H-SiC Faces: *Biplob Daas*¹; KM Daniels¹; S. Shetu¹; TS Sudarshan¹; MVS Chandrashekar¹; ¹University of South Carolina

10:00 AM Break

10:20 AM Student

T5, Synthesis of a Pillared Graphene Nanostructure: A Three-Dimensional Hybrid Carbon Architecture: *Maziar Ghazinejad*¹; Shirui Gue¹; Rajat Paul¹; Mihri Ozkan¹; Cengiz Ozkan¹; ¹University of California, Riverside

10:40 AM Student

T6, Electrochemical Graphane Conversion Using E-Beam Evaporated Metals for Catalytic Enhancement: *Kevin Daniels*¹; Biplob Daas¹; Rui Zhang¹; John Weidner¹; Christopher Williams¹; Tangali Sudarshan¹; MVS Chandrashekar¹; ¹University of South Carolina

11:00 AM

T7, Highly Reproducible Growth of Carbon Nanotubes for Practical Applications in Electronics: *Yohei Yagishita*¹; Daiyu Kondo¹; Ikuo Soga¹; Taisuke Iwai¹; ¹Fujitsu Laboratories Ltd

11:20 AM

T8, Graphene and Carbon Nanotube Growth in Vacuum Systems: *Bruce Willner*¹; Tom Salagaj¹; Virgil Shields²; Michael Spencer²; Nick Sbrockey¹; Gary Tompa¹; ¹Structured Materials Industries, Inc.; ²Cornell University

11:40 AM T9, Late News

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Session U: Highly Mismatched Alloys

Thursday AM
June 23, 2011

Room: Santa Barbara Harbor
Location: University of California-Santa Barbara

Session Chairs: Rachel Goldman, University of Michigan; Joshua Zide, University of Delaware

8:20 AM Student

U1, Synthesis of $\text{Ge}_{(1-x)}\text{Sn}_x$ Alloy Thin Films Using Ion-Implantation and Pulsed Laser Melting (II-PLM): *Ashish Bhatia*¹; Win Hlaing Oo¹; Gene Siegel¹; Peter Stone²; Kin-Man Yu²; Michael Scarpulla¹; ¹Materials Science and Engineering, University of Utah; ²Lawrence Berkeley National Laboratory, Berkeley

8:40 AM

U2, Nitrogen Ordering in Ga(NAs) at the Atomic Scale: Vivien Voßbünger¹; Lena Ivanova²; Andrea Lenz²; Nadine Oswald²; Kakhber Jandieri¹; Mario Dähne²; Wolfgang Soltz¹; Kerstin Volz¹; *Holger Eisele*²; ¹Philipps University Marburg; ²Technische Universität Berlin

9:00 AM Student

U3, Band Edge Optical Transitions in Bulk GaSbN and InAsN Dilute-Nitride Materials: *Ding Wang*¹; Stefan Svensson²; Leon Shterengas¹; Gregory Belenky¹; ¹SUNY at Stony Brook; ²Army Research Laboratory

9:20 AM Student

U4, Highly Mismatched $\text{GaN}_{1-x}\text{As}_x$ Alloys across the Entire Composition Range: *Alejandro Levander*¹; Sergei Novikov²; Zuzanna Liliental-Weber¹; Iraida Demchenko³; Jonathan Denlinger¹; Franziska Luckert³; Robert Martin³; Oscar Dubon⁴; Tom Foxon²; Junqiao Wu⁴; Wladek Walukiewicz¹; Kin-Man Yu¹; ¹Lawrence Berkeley National Laboratory; ²University of Nottingham; ³Strathclyde University; ⁴University of California - Berkeley

9:40 AM Student

U5, A Study of MBE Grown $\text{InSb}_{1-x}\text{N}_x$ on GaAs for Long-Wavelength IR Applications: *Nimai Patra*¹; Sudhakar Bharatan¹; Jia Li¹; Shanthi Iyer¹; ¹North Carolina A&T State University

10:00 AM Break

10:20 AM Student

U6, Non-Monotonic Change/Variation in the Seebeck Coefficient of $\text{GaAs}_{1-x}\text{N}_x$ Thin Film Thermoelectrics Due to the Addition of N ($x = 0.5\%$ to 1.5%): *Paothep Pichanusakorn*¹; Yanjin Kuang²; Prabhakar Bandaru¹; Charles Tu²; Hua Li²; Calvin Patel¹; ¹UCSD-MATS; ²UCSD-ECE

10:40 AM Student

U7, $\text{GaN}_{1-x}\text{Bi}_x$: Extremely Mismatched Alloys: *Alejandro Levander*¹; Sergei Novikov²; Zuzanna Liliental-Weber¹; Alex Tseng³; Jonathan Denlinger¹; Oscar Dubon³; Tom Foxon²; Junqiao Wu³; Wladek Walukiewicz¹; Kin-Man Yu¹; ¹Lawrence Berkeley National Laboratory; ²University of Nottingham; ³University of California - Berkeley

11:00 AM Student

U8, Electrical and Thermal Properties of $\text{InGaBi}_x\text{As}_{1-x}$: *Pernell Dongmo*¹; John Petropoulos¹; Yujun Zhong¹; Joshua Zide¹; ¹University of Delaware

11:20 AM

U9, Incorporation of Bismuth into GaAs and InAs Grown by Molecular-Beam Epitaxy: *Aaron Ptak*¹; Ryan France¹; ¹NREL

11:40 AM Student

U10, Highly Mismatched Oxide Alloy for Photovoltaic and Photoelectrochemical Applications: *Marie Mayer*¹; Derrick Speaks¹; Roberto dos Reis¹; Zuzanna Liliental-Weber¹; Kin Man Yu¹; Samuel Mao¹; Eugene Haller¹; Wladek Walukiewicz¹; ¹LBNL

Session V: Organic Photovoltaics and Photoelectrochemical Cells

Thursday AM
June 23, 2011

Room: State Street
Location: University of California-Santa Barbara

Session Chairs: David Janes, Purdue University; David Gundlach, National Institute of Standards and Technology

8:20 AM Invited

V1, Alkanethiol Island Formation on Single Crystal Zinc Oxide Surfaces: Andrea Yocom¹; Darick Baker¹; Thomas Brenner¹; Heather Hunt¹; Dana Olson¹; Thomas Furtak¹; Timothy Ohno¹; *Reuben Collins*¹; ¹Colorado School of Mines

9:00 AM

V2, Improved High Efficiency Organic Solar Cells via Incorporation of a Conjugated Polyelectrolyte Interlayer: *Jung Hwa Seo*¹; Andrea Gutacker²; Yanming Sun³; Hongbin Wu⁴; Fei Huang⁴; Yong Cao Cao⁴; Ullrich Scherf²; Alan J. Heeger Heeger²; Guillermo C. Bazan³; ¹Dong-A University; ²Bergische Universitaet Wuppertal; ³University of California Santa Barbara; ⁴South China University of Technology

9:20 AM Student

V3, A Systematic Approach to Solvent Selection Based on Cohesive Energy Densities in a Molecular Bulk Heterojunction System: *Bright Walker*¹; Arnold Tamayo²; Duc Duong¹; Xuan-Dung Dang¹; Chunki Kim¹; Jimmy Granstrom¹; Thuc-Quyen Nguyen¹; ¹University of California Santa Barbara; ²Colorado School of Mines

9:40 AM Student

V4, Structure-Function-Property Relationships of Diketopyrrolopyrrole-Based Materials for Applications in Solution Processed Organic Solar Cells: *Jason Lin*¹; ¹UCSB

10:00 AM Break

10:20 AM Student

V5, ALD-TiO₂ to Enable Si as a Corrosion Resistant Photoelectrode for Water Oxidation and in Photoelectrochemical Solar Cells: *Yi Wei Chen*¹; Jonathan Prange¹; Marika Gunji¹; Christopher Chidsey¹; Paul McIntyre¹; ¹Stanford University

10:40 AM

V6, Performance Optimization of Branched Nanowire Heterostructure-Based Photoelectrochemical Cells for Water Solar Splitting: *Alireza Kargar*¹; Ke Sun¹; Deli Wang¹; ¹UC San Diego

11:00 AM

V7, Layer-By-Layer Assembly of Light Harvesting Arrays for Molecular Based Solar Cells: *Peter Dinolfo*¹; ¹Rensselaer Polytechnic Institute

11:20 AM Student

V8, Low Temperature Fabrication of Hybrid Carbon Nanotube Gel as a Counter Electrode for Efficient Dye Sensitized Solar Cells: *Gede Adhyaksa*¹; Jin Park¹; Ga Lee¹; Jeung Kang¹; ¹KAIST

11:40 AM V9, Late News

Technical Program

Session W: III-Nitride: Bulk Growth and Epitaxy

Thursday PM
June 23, 2011
Room: Corwin East
Location: University of California-Santa Barbara

Session Chairs: Theeradetch Detchprohm, Rensselaer Polytechnic Institute;
Edwin Piner, Texas State University

1:30 PM Student

W1, Shape Transformation of Nanoporous GaN by Annealing: Buried Cavities and Nanomembranes: *Christopher Yerino*¹; Yu Zhang¹; Benjamin Leung¹; Jung Han¹; ¹Yale University

1:50 PM Student

W2, Bulk GaN Growth on GaN Seeds of Varying Orientations in Supercritical Basic Ammonia: *Siddha Pimputkar*¹; Shinichiro Kawabata²; James Speck¹; Shuji Nakamura¹; ¹Materials Department, University of California - Santa Barbara; ²Optoelectronics Laboratory, Mitsubishi Chemical Corporation

2:10 PM Student

W3, Large-Area, Free Standing GaN by an Novel Nanoetching Process and Substrate Recycling: *Yu Zhang*¹; Qian Sun¹; Benjamin Leung¹; John Simon¹; Minjoo Lee¹; Jung Han¹; ¹Yale University

2:30 PM Student

W4, Effect of Strain on Effective Masses in GaN and AlN: *Cyrus Dreyer*¹; Anderson Janotti¹; Chris Van de Walle¹; ¹University of California, Santa Barbara

2:50 PM Student

W5, Quasi Equilibrium Crystal Shapes and Kinetic Wulff Plots of Gallium Nitride Grown by Hydride Vapor Phase Epitaxy: *Benjamin Bryant*¹; Asako Hirai¹; Shuji Nakamura¹; James Speck¹; ¹University of California, Santa Barbara

3:10 PM Break

3:30 PM Student

W6, In Situ Stress Measurements during GaN Growth on Ion Implanted AlN/Si Substrates: *Jarod Gagnon*¹; Mihir Tungare²; Xiaojun Weng³; Fatemeh (Shadi) Shahedipour-Sandvik²; Joan Redwing¹; ¹Pennsylvania State University; ²The College of Nanoscale Science and Engineering, University at Albany; ³The Materials Research Institute

3:50 PM Student

W7, Effect of Indium Surfactant on N-Polar GaN Epilayers Grown by Metalorganic Chemical Vapor Deposition: *Dongjin Won*¹; Xiaojun Weng¹; Joan Redwing¹; ¹The Pennsylvania State University

4:10 PM Student

W8, Schottky Barrier Height and Interface Chemistry for Metals Contacted to Low Dislocation Density AlGaIn Grown on C-Oriented AlN Wafers: *James Tweedie*¹; Anthony Rice¹; Ramon Collazo¹; Seiji Mita²; Jinqiao Xie²; Zlatko Sitar¹; ¹North Carolina State University; ²Hexatech, Inc.

4:30 PM Student

W9, Generation Mechanism of Threading Dislocations in Heteroepitaxial Growth of 2H-AlN on 6H-SiC (0001) Substrates: *Hironori Okumura*¹; Tsunenobu Kimoto¹; Jun Suda¹; ¹Kyoto University

4:50 PM

W10, Impact of AlN Wetting Layer on the Strain Development in GaN Layer Grown on Chemical Mechanical Polished 4H - SiC Substrates: *Eunjung Cho*¹; Frank Brunner¹; Markus Weyers¹; ¹Ferdinand-Braun-Institut

Session X: Oxide Thin Films

Thursday PM
June 23, 2011
Room: Corwin West
Location: University of California-Santa Barbara

Session Chairs: John Conley, Oregon State University; Patrick Lenahan, Pennsylvania State University

1:30 PM Student

X1, Gate First In_{0.53}Ga_{0.47}As/Al₂O₃ MOSFETs with In-Situ Channel Surface Cleaning: *Andrew Carter*¹; Jeremy Law¹; William Mitchell¹; Gregory Burek¹; Brian Thibeault¹; Arthur Gossard¹; Mark Rodwell¹; ¹UC Santa Barbara

1:50 PM Student

X2, Structure of Electronic Defects near the SiC/SiO₂ Interface: *Corey Cochrane*¹; Patrick Lenahan¹; Aivars Lelis²; ¹Pennsylvania State University; ²Army Research Lab

2:10 PM

X3, Interface State Density for Positive Band Offset Dielectrics (Al₂O₃, SiO₂) on GaN: *Ramya Yeluri*¹; Jing Lu¹; Xiang Liu¹; Brian Swenson¹; Umesh Mishra¹; Guangle Zhou²; Huili Xing²; ¹University of California Santa Barbara; ²University of Notre Dame

2:30 PM Student

X4, Comparison of Metal Deposition Methods by CV Analysis of ALD Al₂O₃ on In_{0.53}Ga_{0.47}As: *Gregory Burek*¹; Andrew Carter¹; Jeremy Law¹; Brian Thibeault¹; William Mitchell¹; Mark Rodwell¹; ¹Electrical Engineering Department UCSB

2:50 PM Student

X5, Passivation Effects of ALD Oxides on Self-Aligned In_{0.53}Ga_{0.47}As/InAs/InP Vertical Tunnel FETs: *Guangle Zhou*¹; Yeqing Lu¹; Rui Li¹; Tim Vasen¹; Qingmin Liu¹; Wan Sik Hwang¹; Qin Zhang¹; Haijun Zhu²; Jenn-Ming Kuo²; Siyuranga Koswatta³; Mark Wistey¹; Tom Kosel¹; Patrick Fay¹; Alan Seabaugh¹; Huili Xing¹; ¹University of Notre Dame; ²IntelliEPI; ³IBM T. J. Watson Research Center

3:10 PM Break

3:30 PM Student

X6, Influence of Trimethylaluminum (TMA) Exposure on the Growth and Electrical Characteristics of HfO₂/In_{0.53}Ga_{0.47}As Gate Stacks: *Yoontae Hwang*¹; Varistha Chobpattana¹; Roman Engel-Herbert²; Susanne Stemmer¹; ¹University of California, Santa Barbara; ²Pennsylvania State University

3:50 PM Student

X7, Investigation of Electrode Roughness and High-K Dielectric Barrier on Metal-Insulator-Metal Tunnel Diode Operation: *Nasir Alimardani*¹; E. Cowell¹; John Wager¹; John Conley¹; ¹Oregon State University

4:10 PM

X8, Co-Sputtering of Barium Strontium Titanate (BST) and Barium Oxide-Boron Oxide Flux (BaO-B₂O₃) for Thin Film Applications: *Peter Lam*¹; David Harris¹; Jon-Paul Maria¹; ¹North Carolina State University

4:30 PM Student

X9, Solution-Processed Zirconium Oxide and Integration with Zinc-Tin Oxide Thin-Film Transistors: *Chen-Guan Lee*¹; Ananth Dodabalapur¹; ¹University of Texas at Austin

4:50 PM

X10, Epitaxial LaAlO₃/SrTiO₃ Heterostructures by Atomic Layer Deposition: *Nick Sbrockey*¹; Michael Luong¹; Eric Gallo²; Jennifer Sloppy²; Guannan Chen²; Christopher Winkler²; Stephanie Johnson²; Mitra Taheri²; Jonathan Spanier²; Gary Tompa¹; ¹Structured Materials Industries, Inc.; ²Drexel University

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Session Y: Point, Defects, Doping and Extended Defects

Thursday PM
June 23, 2011

Room: Flying A
Location: University of California-Santa Barbara

Session Chairs: Andrew Armstrong, Sandia National Laboratories; Emre Gur, Ohio State University

1:30 PM

Y1, The Influence of Al Composition on AlGa_N Point Defect Incorporation: *Tania Henry*¹; Andrew Armstrong¹; Andrew Allerman¹; Mary Crawford¹; ¹Sandia National Laboratories

1:50 PM Student

Y2, Hybrid Functional Calculations of DX Centers in AlN, GaN and AlGa_N: *Luke Gordon*¹; John L. Lyons¹; Anderson Janotti¹; Chris G. Van de Walle¹; ¹University of California, Santa Barbara

2:10 PM Student

Y3, Deep Traps in M-Plane GaN Grown by Ammonia MBE: *Zeng Zhang*¹; Christophe Hurri²; Aaron Arehart¹; James Speck²; Steven Ringel¹; ¹The Ohio State University; ²University of California Santa Barbara

2:30 PM

Y4, Intrinsic Surface States and Dislocations at GaN(10-10) Surfaces Investigated by Scanning Tunneling Microscopy: *Holger Eisele*¹; Lena Ivanova¹; Svetlana Borisova²; Mario Dähne¹; Philipp Ebert²; ¹Technische Universität Berlin; ²Forschungszentrum Jülich GmbH

2:50 PM

Y5, Defect Characterization of InGa_N Layer by Deep Level Transient and Optical Spectroscopies: *Emre Gur*¹; Sriram Krishnamoorthy¹; Zeng Zhang¹; Siddharth Rajan¹; Steven Ringel¹; ¹Ohio State University

3:10 PM Break

3:30 PM Student

Y6, Observation of *m*-Plane Slip and Relaxation Orthogonal to the Projected *c*-Direction in (20-21) InGa_N/GaN Partially Relaxed Layers: *Matthew Hardy*¹; Feng Wu¹; Po Shan Hsu¹; Ingrid Koslow¹; Erin Young¹; James Speck¹; Steven DenBaars¹; ¹UC Santa Barbara

3:50 PM Student

Y7, Misfit Dislocation Formation in Partially Strain-Relaxed (11-22) Semipolar InGa_N: *Po Shan Hsu*¹; Erin Young¹; Alexey Romanov¹; Kenji Fujito¹; James Speck¹; Shuji Nakamura¹; ¹Materials Department, University of California, Santa Barbara

4:10 PM Student

Y8, Stress Mapping Analysis by Ray Tracing (SMART): A New Technique for Residual Strain/Stress Measurement of Single Crystal Material Using Synchrotron White Beam: *Vishwanath Sarkar*¹; Balaji Raghothamachar¹; Michael Dudley¹; ¹SUNY at Stony Brook

4:30 PM Student

Y9, Charged Basal Stacking Fault (BSF) Scattering in Wide Band-Gap Semiconductors: *Aniruddha Konar*¹; Tian Fang¹; Nan Sun¹; Debdeep Jena¹; ¹University of Notre Dame

4:50 PM Student

Y10, Hydrogen-Related Cathodoluminescence in Mg-Doped GaN: *Reid Juday*¹; Kwei Sun¹; Alec Fischer¹; Fernando Ponce¹; Hee Jin Kim²; Suk Choi²; Jeomoh Kim²; Mi-Hee Ji²; Jae-Hyun Ryou²; Russell Dupuis²; ¹Arizona State University; ²Georgia Institute of Technology

Session Z: Epitaxial Materials and Devices I

Thursday PM
June 23, 2011

Room: Lobero
Location: University of California-Santa Barbara

Session Chairs: Christine Wang, Massachusetts Institute of Technology, Lincoln Laboratory; Charles Lutz, Kopin Corporation

1:30 PM Student

Z1, Growth of Epitaxially-Embedded ErAs Films in GaAs: *Adam Crook*¹; Hari Nair¹; Domingo Ferrer¹; Seth Bank¹; ¹University of Texas at Austin

1:50 PM Student

Z2, Improved Conductivity of GaAs-Based Tunnel Junctions Containing ErAs Nanostructures via Compositional Grading: *Rodolfo Salas*¹; Erica Krivoy¹; Adam Crook¹; Hari Nair¹; Seth Bank¹; ¹University of Texas at Austin

2:10 PM Student

Z3, Photoluminescence from the Direct Bandgap of Ge_{1-x}Sn_x Alloys Grown by Molecular Beam Epitaxy: *Robert Chen*¹; Hai Lin¹; Yijie Huo¹; Suyog Gupta¹; Krishna Saraswat¹; Ted Kamins¹; James Harris¹; ¹Stanford

2:30 PM

Z4, Fabrication and Characterization of Whispering Galley Mode (WGM) Microdisk Resonator Based on Epitaxially Grown GeSn: *Seongjae Cho*¹; Robert Chen¹; Hai Lin¹; Yijie Huo¹; Gary Shambat¹; Jelena Vuckovic¹; Theodore Kamins¹; Byung-Gook Park¹; James Harris¹; ¹Stanford University

2:50 PM Student

Z5, Raman Study of Strained Ge_{1-x}Sn_x Alloys: *Hai Lin*¹; Robert Chen²; Yijie Huo²; Theodore Kamins²; James Harris²; ¹Materials Science and Engineering; ²Electrical Engineering

3:10 PM Break

3:30 PM

Z6, Study of Molecular Beam Epitaxial Grown HgCdSe for Infrared Applications: *Gregory Brill*¹; Yuanping Chen¹; Priyalal Wijewarnasuriya¹; ¹U.S. Army Research Laboratory

3:50 PM Student

Z7, XMCD Measurement of Molecular Beam Epitaxy γ -Fe₂N Thin Films on LaAlO₃(100) and MgO(100) Substrates: *Keita Ito*¹; Geunhyoung Lee¹; Kazunori Harada¹; Mao Ye²; Yukiharu Takeda³; Yuji Saitoh³; Takashi Suemasu¹; Akio Kimura²; Hiro Akinaga⁴; ¹University of Tsukuba; ²Hiroshima University; ³JAEA; ⁴AIIST

4:10 PM

Z8, Sb Surfactant Use during GaInP and GaInAs Strain Relaxation: *Ryan France*¹; William McMahon¹; John Geisz¹; Aaron Ptak¹; Myles Steiner¹; Bobby To¹; Manuel Romero¹; Waldo Olavarria¹; ¹National Renewable Energy Laboratory

4:30 PM Student

Z9, Sensitivity of Strained and Unstrained Structure Growth on GaAs (111) B: *Denzil Roberts*¹; David Mueller¹; Gregory Triplett¹; ¹University of Missouri

4:50 PM

Z10, Ternary In_xGa_{1-x}As Nanowires on Silicon Substrates: 1D Heterogeneous Epitaxy, Bandgap Engineering, and Photovoltaics: *Jae Cheol Shin*¹; *Xiuling Li*¹; ¹University of Illinois

Technical Program

Session AA: Four Dots and a Dash

Thursday PM Room: Lotte Lehmann
June 23, 2011 Location: University of California-Santa Barbara

Session Chairs: Akio Sasaki, Kyoto University; James Merz, University of Notre Dame

1:30 PM
AA1, Self-Assembled, Tensile-Strained III-V Islands on (110) and (111)A Substrates: *Paul Simmonds*¹; Minjoo Larry Lee²; ¹Yale University

1:50 PM
AA2, Atomic Structure of InAs/InGaAsP/InP(001) Quantum Dashes and Decomposition of the InGaAsP Matrix Material: *Andrea Lenz*¹; Holger Eisele¹; Florian Genz¹; Lena Ivanova¹; Rainer Timm¹; Dieter Franke²; Harald Künzel²; Udo Pohl¹; Mario Dähne¹; ¹Technische Universität Berlin; ²Fraunhofer Heinrich Hertz Institut

2:10 PM Student
AA3, Photoluminescence and Thermal Carrier Activation in Type-II ZnTe/ZnSe Quantum Dots: *Bor-Chau Juang*¹; Weiming Wang¹; Jamie Phillips¹; ¹University of Michigan, Ann Arbor

2:30 PM Student
AA4, Temperature Dependent Photoluminescence of Ensemble and Single InAs/InGaAlAs Quantum Dots: *Nahid Jahan*¹; Claus Hermannstädter¹; Jae-Hoon Huh¹; Hirotaka Sasakura¹; K. Akahane²; M. Sasaki²; Pankaj Ahirwar²; Thomas J. Rotter³; Ganesh Balakrishnan³; Hidekazu Kumano¹; Ikuo Suemune¹; ¹Laboratory of Nano-photonics; ²National Institute of Information and Communication Technology; ³Center for High Technology Materials

2:50 PM
AA5, Atomic Structure and Optical Properties of Submonolayer InAs/GaAs Depositions: *Andrea Lenz*¹; *Holger Eisele*¹; Jonas Becker¹; Jan-Hendrick Schulze¹; Tim Germann¹; Franziska Luckert¹; Konstantin Pötschket¹; Ernst Lenz¹; Lena Ivanova¹; Andre Strittmatter¹; Udo Pohl¹; Mario Dähne¹; Dieter Bimberg¹; ¹Technische Universität Berlin

3:10 PM Break

Session BB: Fundamentals of Low-Dimensional Structures

Thursday PM Room: Lotte Lehmann
June 23, 2011 Location: University of California-Santa Barbara

Session Chairs: Glenn Solomon, National Institute of Standards and Technology; James Merz, University of Notre Dame

3:30 PM Student
BB1, Local Density of States and Semimetallic Behavior of Rare Earth-V Nanoparticles Embedded in a III-V Semiconductor Matrix: *Jason Kawasaki*¹; Rainer Timm²; Trevor Buehl¹; Edvin Lundgren²; Arthur Gossard¹; Anders Mikkelsen²; Chris Palmstrom¹; ¹University of California Santa Barbara; ²Lund University

3:50 PM Student
BB2, A Simple Thermodynamic Model for the Doping and Alloying of Nanoparticles: *John Petropoulos*¹; Thomas Cristiani¹; Pernell Dongmo¹; Joshua Zide¹; ¹University of Delaware

4:10 PM Student
BB3, Band Structure and Thermal Escape Processes of Strained InGaSb/AlGaSb Quantum Wells: *Nahid Jahan*¹; Hitoshi Iijima¹; Claus Hermannstädter¹; Thomas Rotter²; Pankaj Ahirwar²; Ganesh Balakrishnan²; Hidekazu Kumano¹; Ikuo Suemune¹; ¹Hokkaido University; ²University of New Mexico

4:30 PM Student
BB4, Formation and Templating of III-V Semiconductor Nanospikes by Focused Ion Beams: *Kevin Grossklaus*¹; Joanna Millunchick¹; ¹University of Michigan

4:50 PM Student
BB5, A Detailed Temperature-Dependent Photoluminescence Investigation into the Growth Pause Induced Ripening of InAs/GaAs Quantum Dot Heterostructures: *Rahul Makhijani*¹; Saumya Sengupta¹; Subhananda Chakrabarti¹; ¹Indian Institute of Technology Bombay

Session CC: Graphene Characterization and Applications

Thursday PM Room: Multicultural Center Theatre
June 23, 2011 Location: University of California-Santa Barbara

Session Chairs: Huili Grace Xing, University of Notre Dame; M.V.S. Chandrashekar, Cornell University

1:30 PM
CC1, In Situ High-Temperature Scanning Tunneling Microscopy Studies of Graphene Growth on 6H-SiC(0001): *Suneel Kodambaka*¹; Yuya Murata¹; Vania Petrova²; Ivan Petrov²; ¹University of California, Los Angeles (UCLA); ²Frederick Seitz Materials Research Laboratory, University of Illinois Urbana-Champaign

1:50 PM
CC2, Electrical Characterization of Graphene-Semiconductor Heterojunctions: *Travis Anderson*¹; Karl Hobart¹; Luke Nyakiti¹; Virginia Wheeler¹; Rachel Myers-Ward¹; Boris Feigelson¹; Joshua Caldwell¹; Francisco Bezares¹; Jennifer Hite¹; Michael Mastro¹; D Gaskill¹; Charles Eddy¹; Francis Kub¹; Glenn Jernigan¹; ¹Naval Research Laboratory

2:10 PM Student
CC3, Correlated Conductivity and Work Function in Epitaxial Graphene: *Mohammad Nomani*²; Amol Singh¹; Goutam Koley¹; Virgil Shields²; Mike Spencer²; Gary Tompa³; Nick Sbrockey³; ¹University of South Carolina; ²Cornell University; ³Structured Materials Industries, Inc.

2:30 PM
CC4, Response of Graphene-Based Field Effect Devices Exposed to Gamma and Neutron Irradiation: *Mark Fanton*¹; Joshua Robinson¹; Michael LaBella¹; Randal Cavalero¹; Brenden Heidrich¹; Matthew Hollander¹; Zachery Hughes¹; Kathleen Trumbull¹; ¹Penn State University

2:50 PM Student
CC5, Surface Adsorption and Charge Transport in Epitaxial Graphene on 6H-SiC: *Shamaita Shetti*¹; MWK Nomani¹; Goutam Koley¹; MVS Chandrashekar¹; ¹University of South Carolina

3:10 PM Break

3:30 PM Student
CC6, Graphene Reinforced Composites as Efficient Thermal Interface Materials: *Khan Shahil*¹; Samia Subrina¹; Alexander Balandin¹; ¹University of California, Riverside (UCR)

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3:50 PM Student

CC7, Frequency Domain THz Characterization of Graphene: *Berardi Sensale-Rodriguez*¹; Rusen Yan¹; Michelle Kelly¹; Tian Fang¹; Kristof Tahy¹; Debdeep Jena¹; Lei Liu¹; Huili Grace Xing¹; ¹University of Notre Dame

4:10 PM

CC8, Charge Carrier Dynamics in Graphene: Suspended vs. Supported: *Bo Gao*¹; Libai Huang¹; Gregory Hartland¹; Michelle Kelly¹; Huili Xing¹; Debdeep Jena¹; ¹University of Notre Dame

4:30 PM Student

CC9, Polariton Enhanced IR-Reflectivity of Epitaxial Graphene on SiC: *Biplob Das*¹; KM Daniels¹; S. Shetu¹; W.K. Nomani¹; Goutam Koley¹; T.S. Sudarshan¹; MVS Chandrashekar¹; ¹University of South Carolina

4:50 PM Student

CC10, Centimeter-Scale Metrology of CVD Graphene on Glass: *Jennifer Reiber Kyle*¹; Ali Guvenc¹; Wei Wang¹; Jian Lin¹; Maziar Ghazinejad¹; Cengiz Ozkan¹; Mihrimah Ozkan¹; ¹University of California Riverside

4:10 PM

DD8, Unexpected Exchange-Bias Effect at Paramagnetic/Ferromagnetic Interfaces in Oxide-Based Structures: *Laura Steren*¹; Juan Rojas Sanchez²; Brittain Nelson-Cheeseman³; Mara Granada⁴; E. Arenholz⁵; ¹Centro Atomico Constituyentes; ²Centro Atomico Bariloche; ³University of California; ⁴Laboratoire de Photonique et Nanostructures-CNRS; ⁵Lawrence Berkeley National Laboratory

4:30 PM Student

DD9, Formation of Half-Metallic Ferromagnet Tunnel Junctions of Co₂FeSi/SiO_xN_y/Si Using Radical Oxynitridation Technique: *Yota Takamura*¹; Kengo Hayashi¹; Yusuke Shuto²; Satoshi Sugahara²; ¹Dept. of Electronics and Appl. Phys., Tokyo Inst. of Tech.; ²ISEL, Tokyo Inst. of Tech., and CREST, JST

4:50 PM Student

DD10, Characterization of L₂-Ordered Full-Heusler Co₂FeSi_{1-x}Al_x Alloy Thin Films Formed by Silicidation Technique Employing Silicon-on-Insulator Substrate: *Mitsuhiro Satoh*¹; Yota Takamura¹; Satoshi Sugahara²; ¹Dept. of Electronics and Appl. Phys., Tokyo Inst. of Tech.; ²ISEL, Tokyo Inst. of Tech., and CREST, JST

Session DD:

Nano-Magnetic, Magnetic Memory and Spintronic Materials

Thursday PM Room: Santa Barbara Harbor
June 23, 2011 Location: University of California-Santa Barbara

Session Chairs: Michael Flatte, Univ of Iowa; Xinyu Liu, Univ of Notre Dame

1:30 PM Student

DD1, Enhanced Spin Injection and Spin Lifetimes in Graphene: *Wei Han*¹; Roland Kawakami¹; ¹University of California, Riverside

1:50 PM Student

DD2, Enhancement of Spin Torque by Proximity to Other Domain Walls: *Elizabeth Golovatski*¹; Michael Flatte¹; ¹University of Iowa

2:10 PM Student

DD3, Spin Seebeck Effect in MnAs/GaMnAs Bilayers: *Kurtis Wickey*¹; Christopher Jaworski²; Jing Yang³; Shawn Mack⁴; David Awschalom⁴; Joseph Heremans²; Roberto Myers³; Ezekiel Johnston-Halperin¹; ¹Physics Department, The Ohio State University; ²Mechanical Engineering Department, The Ohio State University; ³Materials Science and Engineering Department, The Ohio State University; ⁴Center for Spintronics and Quantum Computation, UCSB

2:30 PM

DD4, Universal Valence-Band Picture of the Ferromagnetic Semiconductor GaMnAs Obtained by the Resonant Tunneling Spectroscopy: *Shinobu Ohya*¹; Kenta Takata¹; Yufei Xin¹; Masaaki Tanaka¹; ¹The University of Tokyo

2:50 PM Student

DD5, Fe₃O₄/GaAs Hybrid Ferromagnet/Semiconductor Nanostructures: *Paul Riechers*¹; Jun Chen²; Christopher Murray²; Richard Kiehl¹; ¹UC Davis; ²University of Pennsylvania

3:10 PM Break

3:30 PM Student

DD6, Magnetic Depth Profile of Mn-Graded (Ga,Mn)As: *J. Leiner*¹; B. Kirby²; K. Tivakornasithorn¹; Xinyu Liu¹; J. Furdyna¹; M. Dobrowolska¹; ¹University of Notre Dame; ²National Institute of Standards and Technology

3:50 PM

DD7, Manganese-Doping of Group IV Semiconductor Surfaces and Nanostructures: Christopher Nolph¹; Kiril Simov¹; Catherine Jenkins²; Anders Glans²; *Petra Reinke*¹; ¹University of Virginia; ²Lawrence Berkeley National Laboratory

Session EE:

Organic Thin Film and Crystalline Transistors: Devices and Materials

Thursday PM Room: State Street
June 23, 2011 Location: University of California-Santa Barbara

Session Chairs: Alberto Salleo, Stanford University; David Gundlach, National Institute of Standards and Technology

1:30 PM Student

EE1, Quantitative Analysis of Lattice Disorder and Crystallite Size in Organic Semiconductor Thin Films, and Implications for Charge Transport: *Jonathan Rivnay*¹; Rodrigo Noriega¹; Michael Toney²; John Northrup³; R. Kline⁴; Alberto Salleo¹; ¹Stanford University; ²Stanford Synchrotron Radiation Lightsource; ³Palo Alto Research Center; ⁴NIST

1:50 PM Student

EE2, Following Charge-Trapping Chemical Reactions in Pentacene Films by Selective Chemical Doping and Wavelength-Resolved Electric Force Microscopy: *Louisa Brown*¹; Vladimir Pozdin¹; Justin Luria¹; Chad Lewis¹; John Marohn¹; ¹Cornell University

2:10 PM Student

EE3, Molecular Contact Doping for Organic n-Channel TFTs and Fast Complementary Circuits: *Frederik Antel*¹; Tobias Canzler²; Jan Blochwitz-Nimoth²; Florian Letzkus³; Joachim Burghartz³; Ute Zschieschang¹; Hagen Klauk¹; ¹Max Planck Institute for Solid State Research; ²Novald AG; ³IMS CHIPS

2:30 PM Student

EE4, Charge Trapping and Localization Due to Paracrystalline Disorder in High Performance Polymeric Semiconductors: *Rodrigo Noriega*¹; Jonathan Rivnay¹; John Northrup²; R. Joseph Kline³; Michael Toney⁴; Alberto Salleo¹; ¹Stanford University; ²Palo Alto Research Center; ³NIST; ⁴Stanford Synchrotron Radiation Lightsource

2:50 PM Student

EE5, Probing the Microstructure of Buried Polymer-Polymer Interfaces with Thin Film Transistors: *Justin Cochran*¹; Michael Chabiny¹; ¹University of California Santa Barbara

3:10 PM Break

3:30 PM

EE6, Organic Electrochemical Transistors: Working Principle and Applications in Sensing: *Fabio Cicoira*¹; George Malliaras; ¹CNR

3:50 PM Invited

EE7, Materials Requirements for Low-Voltage Flexible Organic Transistors and Circuits: *Hagen Klauk*¹; ¹Max Planck Institute for Solid State Research

4:30 PM

EE8, Organic Transistor-Based Memory: *Martin Burkhardt*¹; Abdesselam Jedaa²; Michael Novak²; Marcus Halik²; ¹Materials Department, University of California Santa Barbara; ²Institute of Polymer Materials, University Erlangen-Nürnberg

4:50 PM Student

EE9, From Nano- to Micro-Scale Control of Crystalline Order in Soluble Small-Molecule Organic Semiconductors: *Jeremy Ward*¹; Marsha Loth²; John Anthony²; Oana Jurchescu¹; ¹Wake Forest University; ²University of Kentucky

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Session FF: III-Nitrides: Epitaxy Material and Devices II

Friday AM Room: Corwin East
June 24, 2011 Location: University of California-Santa Barbara

Session Chairs: Seth Bank, University of Texas at Austin; Archie Holmes, University of Virginia

8:20 AM

FF1, n+GaAs Sheet Resistance Saturation and Implications to BiHEMT Growth: Kevin Stevens¹; Nuvee Kunathai¹; Tom Nunes¹; Charles Lutz¹; Wayne Johnson¹; ¹Kopin Corporation

8:40 AM Student

FF2, Metamorphic p-i-n InGaAs Photodetectors Grown by MOCVD: Yan Gao¹; Zhenyu Zhong¹; Hu Liang¹; Yu Geng¹; Shaoqi Feng¹; Kei May Lau¹; Andrew W. Poon¹; ¹HKUST

9:00 AM Student

FF3, Optimized Growth Condition and Dot Geometry in InAs/InGaAs Sub-Monolayer Quantum Dot Infrared Photodetector: Jiayi Shao¹; ¹CHTM at University of New Mexico

9:20 AM

FF4, Epitaxial Growth of InGaAs/InAlAs/InP Quantum Cascade Lasers by Metalorganic Chemical Vapor Deposition: Yong Huang¹; Jae-Hyun Ryou¹; Russell Dupuis¹; Christian Pflugl²; Federico Capasso²; Kewei Sun³; Alec Fischer³; Fernando Ponce³; ¹Georgia Institute of Technology; ²Harvard University; ³Arizona State University

9:40 AM Student

FF5, GaInNAsSb Quantum Wells with Strain-Compensating GaAsP Layers for GaAs-Based 1.55 μm Lasers: Tomas Sarmiento¹; James Harris¹; ¹Stanford University

10:00 AM Break

Session GG: Non-Polar and Semi-Polar III-Nitrides Devices

Friday AM Room: Corwin East
June 24, 2011 Location: University of California-Santa Barbara

Session Chairs: Russell Dupuis, Georgia Institute of Technology; Jae-Hyun Ryou, Georgia Institute of Technology

10:20 AM Student

GG1, Highly Polarized Spontaneous Emission from Semipolar (20-2-1) InGaN/GaN Light-Emitting Diodes: Yuji Zhao¹; Shinichi Tanaka²; Roy Chung²; Chih-Chien Pan²; Kenji Fujito³; Daniel Feezell²; James Speck²; Steven Denbaars¹; Shuji Nakamura¹; ¹Electrical and Computer Engineering Department, University of California, Santa Barbara; ²Materials Department, University of California, Santa Barbara; ³Optoelectronics Laboratory, Mitsubishi Chemical Corporation

10:40 AM Student

GG2, Characterization of Green Semipolar (20-2-1) GaInN/GaN Multiple Quantum Well Light-Emitting Diodes Grown on Freestanding GaN Substrate: Liang Zhao¹; Shi You¹; Christopher Stark¹; Wenting Hou¹; Theeradetch Detchprohm¹; Edward Preble²; Tanya Paskova²; Christian Wetzel¹; ¹Rensselaer Polytechnic Institute; ²Kyma Technologies, Inc.

11:00 AM Student

GG3, Optical Emission Patterns in Semipolar (11-22) GaN Light Emitting Diodes on Planar m-Plane and Etched r-Plane Sapphire: Benjamin Leung¹; Yu Zhang¹; Christopher Yerino¹; Jung Han¹; Bo Kong²; Hyung Cho²; Qian Sun³; Zhen Chen³; Steve Lester³; Kuan Liao⁴; Yun Li⁴; ¹Yale University; ²Sungkyunkwan University; ³Bridgelux, Inc.; ⁴Genesis Photonics Inc.

11:20 AM Student

GG4, Microscopic Optical Properties of Semi-/Nonpolar GaN with InGaN SQWs on Top Grown Directly on Patterned Si Substrate: Sebastian Metzner¹; Frank Bertram¹; Christopher Karbaum¹; Jürgen Christen¹; Shujian Liu²; Natalia Izyumskaya²; Vitaliy Avrutin²; Ümit Özgür²; Hadis Morkoç²; ¹Institute of Experimental Physics, Otto-von-Guericke-University Magdeburg; ²Department of Electrical and Computer Engineering, Virginia Commonwealth University

11:40 AM Student

GG5, Strain Relaxation in Semipolar Nitrides for Optoelectronic Device Applications: Ingrid Koslow¹; Matthew Hardy¹; Po-Shan Hsu¹; Erin Young¹; Shuji Nakamura¹; James Speck¹; Steven Denbaars¹; ¹UCSB Materials

Session HH: Oxide Semiconductors: Growth and Doping

Friday AM Room: Corwin West
June 24, 2011 Location: University of California-Santa Barbara

Session Chairs: Leonard Brillson, Ohio State University; Patrick Kung, University of Alabama

8:20 AM

HH1, Surface Donors Dominate the Conductivity of In₂O₃ Thin Films: Stephan Lany¹; Andriy Zakytayev¹; Thomas Mason²; John Wager³; John Perkins¹; Joseph Berry¹; David Ginley¹; Alex Zunger¹; ¹National Renewable Energy Laboratory; ²Northwestern University; ³Oregon State University

8:40 AM Student

HH2, The Role of Native Point Defects in Highly n-Type Degenerate (Zn,Ga) O Films: Daniel Doutr¹; Snjezana Balaz¹; Louis Isabella¹; Leonard Brillson¹; ¹The Ohio State University

9:00 AM

HH3, High Resolution Photoluminescence Spectroscopy of Donors in Undoped and Indium-Doped ZnO Grown by Metalorganic Vapor Phase Epitaxy: Zhiwei Deng¹; Dichen Li¹; He Huang¹; Simon Watkins¹; ¹Simon Fraser University

9:20 AM Student

HH4, Fermi Level Dependent Li Diffusion in Melt Grown ZnO Proving Amphoteric Behavior of Li: Knut Erik Knutsen¹; Pekka Tapio Neuvonen¹; Klaus Magnus Johansen¹; Bengt Gunnar Svensson¹; Andrej Kuznetsov¹; ¹University of Oslo

9:40 AM Student

HH5, Identification of Acceptor States in Li Doped ZnO Using Nanoscale Depth-Resolved Cathodoluminescence Spectroscopy: Zhichun Zhang¹; K-E. Knutsen²; Andrej Kuznetsov²; Bengt Svensson²; Leonard Brillson¹; ¹Ohio State University; ²University of Oslo

10:00 AM Break

10:20 AM

HH6, Zn(Mg,Cd)O Epitaxy for Optoelectronic Applications: Jizhi Zhang¹; Jin Joo Song²; ¹ZN Technology, Inc.; ²ZN Technology and UCSD

Technical Program

10:40 AM Student

HH7, ZnO and Al₂O₃ Thin Films Deposited by Plasma Enhanced Atomic Layer Deposition and Plasma Enhanced Chemical Vapor Deposition: *Yuanyuan Li¹; J. Ramirez²; Thomas Jackson¹; ¹Penn State University*

11:00 AM Student

HH8, Thin Films of ZnO Prepared by Reactive Pulsed Arc Molecular Beam Deposition: David Eno¹; *Juhyung Yum²; Tingfang Yen²; Robert DeLeon¹; James Garvey¹; Wayne Anderson²; ¹Dept of Chemistry, University at Buffalo; ²Dept of Electrical Engineering, University at Buffalo*

11:20 AM

HH9, Atom Probe Tomography of ZnO Nanowires: Nabil Dawahre¹; Joseph Brewer¹; Gang Shen¹; Nicholas Harris¹; Soner Balci¹; William Baughman¹; Lee Butler¹; Shawn Wilbert¹; Richard Martens¹; Seongsin Kim¹; *Patrick Kung¹; ¹University of Alabama*

11:40 AM

HH10, Strain: A New Strategy of Tuning Doping Site and Type in Semiconductors: *Junyi Zhu¹; Su-huai Wei¹; ¹National Renewable Energy Lab*

Session II:

Intersubband Devices: AlInN and InGaN Materials Characterization

Friday AM Room: Flying A
June 24, 2011 Location: University of California-Santa Barbara

Session Chairs: Oana Malis, Purdue University; Michael Manfra, Purdue University

8:20 AM Student

II1, MBE Growth Study of AlInN and AlInN/GaN Heterostructures for Intersubband Device Applications: *Liang Tang¹; Geoff Gardner¹; Bob Colby¹; Rich Molnar²; Colin Edmunds¹; Michael Manfra¹; Oana Malis¹; ¹Purdue University; ²MIT Lincoln Laboratory*

8:40 AM

II2, Room Temperature near-Infrared AlInN/GaN and AlGaIn/GaN Quantum Well Photodetectors Grown by Molecular Beam Epitaxy: *Colin Edmunds¹; Donghui Li¹; Liang Tang¹; Richard Molnar²; Michael Manfra¹; Oana Malis¹; ¹Purdue University; ²MIT Lincoln Laboratories*

9:00 AM Student

II3, Characterization of Lateral and Vertical Inhomogeneities in InAlN Grown by Plasma-Assisted Molecular Beam Epitaxy: *Wei Kong¹; Wenyuan Jiao¹; Tongho Kim¹; Maria Losurdo²; Giovanni Bruno²; April Brown¹; ¹Duke University; ²Institute of Inorganic Methodologies and of Plasmas*

9:20 AM Student

II4, Electrical Tuning of InGaIn Quantum Dots in GaN Photonic Crystal Cavities: *Alexander Woolf¹; Kasey Russell¹; Fabian Rol¹; Evelyn Hu¹; H.A.R. El-Ella²; M.J. Kappers²; R.A. Oliver²; ¹Harvard; ²Department of Materials Science and Metallurgy, University of Cambridge*

9:40 AM Student

II5, Investigation of Indium and Impurity Incorporation of InGaIn Films on Polar, Nonpolar, and Semipolar GaN Orientations Grown by Ammonia MBE: *David Browne¹; Erin Young¹; James Speck¹; ¹UCSB*

10:00 AM Break

10:20 AM Student

II6, Piezoresponse Force Microscopy of InGaIn/GaN Quantum Dots: *Adrian Bayraktaroglu¹; Meng Zhang¹; Pallab Bhattacharya¹; Jamie Phillips¹; ¹University of Michigan*

10:40 AM Student

II7, InGaIn/GaN Core-Shell Nanorod Arrays Grown by Selective Area Growth for InGaIn-Based Light Emitting Diodes: *Ting-Wei Yeh¹; Lawrence Stewart¹; Hyung-Joon Chu¹; Yen-Ting Lin¹; P. Dapkus¹; ¹Center for Energy Nanoscience, University of Southern California*

11:00 AM

II8, Absence of Electron Accumulation at InN(11-20) Cleavage Surfaces: *Philipp Ebert¹; Sarah Schaafhausen¹; Andrea Lenz²; Aizhan Sabitova¹; Lena Ivanova²; Mario Dähne²; Y.-L. Hong³; Shangji Gwo³; Holger Eisele²; ¹Forschungszentrum Jülich GmbH; ²Technische Universität Berlin; ³National Tsing Hua University*

11:20 AM

II9, Molecular Beam Epitaxial Growth and Characterization of InN Nanocolumns on GaN Templates: *Ke Wang¹; Tomohiro Yamaguchi¹; Tsutomu Araki¹; Euijoon Yoon²; Yasushi Nanishi¹; ¹Ritsumeikan University; ²Seoul National University*

11:40 AM III10, Late News

Session JJ:

Compound Semiconductor Growth on Silicon Substrates

Friday AM Room: Lobero
June 24, 2011 Location: University of California-Santa Barbara

Session Chairs: Thomas Rotter, UNM; Gregory Triplett, University of Missouri-Columbia

8:20 AM Invited

JJ1, Growth Investigations of Lattice-Matched III/V Compound Materials on (001) Si Substrate for Optoelectronics: *Bernardette Kunert¹; Sven Liebich²; Martin Zimprich²; Andreas Beyer²; Stefan Ziegler¹; Kerstin Volz²; Wolfgang Stolz²; ¹NAsP III/V GmbH; ²Material Sciences Center and Department of Physics*

9:00 AM Student

JJ2, Coalescence Phenomena in Narrow-Angle Stripe Epitaxial Lateral Overgrown InP by MOCVD: *Nicholas Julian¹; Philip Mages¹; Steven DenBaars¹; Larry Coldren¹; Pierre Petroff¹; John Bowers¹; ¹University of California, Santa Barbara*

9:20 AM

JJ3, Growth Habit Control of Epitaxial Lateral Overgrown InP on Si Substrates by MOCVD: *Phil Mages¹; Nick Julian¹; Chong Zhang¹; Larry Coldren¹; Steve DenBaars¹; John Bowers¹; ¹Univ. of California Santa Barbara*

9:40 AM

JJ4, Integration of InAs/GaAs Nano/Micro Structures with Silicon by Selective Area Epitaxy: *Guan Huang¹; Faxian Xiu¹; Liang He¹; Yong Wang²; Xufeng Kou¹; Xinxin Yu¹; Kang Wang¹; ¹University of California at Los Angeles; ²University of Queensland*

10:00 AM Break

10:20 AM

JJ5, The Electrical Nature of Structural Defects in InSb Synthesized by Molecular Beam Epitaxy on Si(100) and GaAs(100): *Madhavi Edirisooriya¹; Tong-Ho Kim¹; Aruna Dedigama¹; Yang Yang¹; April Brown¹; ¹Duke University*

10:40 AM

JJ6, Low Leakage Current AlGaIn/GaN HEMTs on Si Substrates with Partially Mg-Doped GaN Buffer Layer by MOCVD: *Li Ming¹; ¹The Hong Kong University of Science and Technology*

FRIDAY
AM

11:00 AM Student

JJ7, Effect of Growth Temperature on Composition of InAlN Alloy Grown by GSMBE on Si (111): *Md Rakib Uddin*¹; Mahesh Pandikunta¹; Vladimir Mansurov¹; Sandeep Sohal²; Georgiy Guryanov³; Mark Holtz²; Sergey Nikishin¹; ¹Nano Tech Center/Department of Electrical and Computer Engineering, Texas Tech University; ²Nano Tech Center/Department of Physics, Texas Tech University; ³Corning Inc.

11:20 AM Student

JJ8, Vapor Phase Epitaxial Growth of (211)B CdTe on Nanopatterned Si for HgCdTe Based Infrared Device Applications: *Shashidhar Shintri*¹; Sunil Rao¹; Charles Schaper²; Ishwara Bhat¹; ¹Rensselaer Polytechnic Institute; ²Transfer Devices

11:40 AM Student

JJ9, Synthesis and Characterization of ZnTe Grown by VLS Method: *Jih-hong Peng*¹; Ebraheem Azhar¹; Ronald Roedel¹; Sandwip Dey¹; Hongbin Yu¹; ¹Arizona State University

Session KK:

Nanowire Growth and Applications

Friday AM
June 24, 2011

Room: Lotte Lehmann
Location: University of California-Santa Barbara

Session Chairs: William Wong, University of Waterloo; Suzanne Mohny, Pennsylvania State University

8:20 AM Student

KK1, Size Effects in Ni Catalyzed Germanium Nanowire Growth: *Shruti Thombare*¹; Ann Marshall¹; Paul McIntyre¹; ¹Stanford University

8:40 AM Student

KK2, Effects of Annealing on Sub-Eutectic Heteroepitaxial Growth of Germanium Nanowire on Si (111) Substrate: *Sung Hwan Chung*¹; Se Jun Park¹; Bong Joong Kim¹; Minghao Qi¹; Xianfan Xu¹; Eric Stach¹; Chen Yang¹; ¹Purdue University

9:00 AM Student

KK3, Catalyzed Vapor-Liquid-Solid Oxidation: Germanium Oxide Nanowires: *Marika Gunji*¹; Shruti Thombare¹; Paul McIntyre¹; ¹Stanford University

9:20 AM

KK4, Catalyst Proximity Effects on the Synthesis of Si Nanowires for In Situ Scanning Electron Microscope Li Intercalation Experiments: *Steven Boles*¹; Andreas Sedlmayer¹; Charles Ho²; Di Chen¹; Oliver Kraft¹; Eugene Fitzgerald²; Reiner Mönig¹; Carl Thompson²; ¹Karlsruhe Institute of Technology; ²Massachusetts Institute of Technology

9:40 AM

KK5, A-Si / Si Nanowire Hybrid Photovoltaics: *Sourobh Raychaudhuri*¹; Rene Lujan¹; Katherine Song¹; Chris Paulson¹; Robert Street¹; ¹Palo Alto Research Center

10:00 AM Break

10:20 AM

KK6, Internal Quantum Efficiency in Nanorod LED Arrays Created by Top-Down Techniques: *Qiming Li*¹; George Wang¹; Karl Westlake¹; Mary Crawford¹; Stephen Lee¹; Daniel Koleske¹; Jeffery Figiel¹; Karen Cross¹; Saeed Fatholouloumi²; Zetian Mi²; ¹Sandia National Laboratories; ²McGill University

10:40 AM Student

KK7, Electrochemically Deposited Branched Indium Antimonide (InSb) Nanowire Arrays as "In-Situ" Anti-Reflective Structures: *Asaduzzaman Mohammad*¹; Suprem Das¹; Mohammad Khan¹; Muhammad Alam¹; David Janes¹; ¹Purdue University

11:00 AM

KK8, Aligned Assembly of Nanowire Arrays with Intrinsic Control: *Kyeong-Sik Shin*¹; Chi On Chui¹; ¹UCLA

11:20 AM

KK9, Nanostructure Decorated AlGaIn/GaN HEMTs for Chemical Sensing: *Shrawan Jha*¹; Igor Bello¹; ¹City University of Hong Kong

11:40 AM

KK10, Environmental Stabilization and Functionalization of ZnO Nanobridge Sensors Fabricated Using Carbonized Photoresist: Ashley Mason¹; Chien-Chih Huang¹; Chris Heist¹; Myra Koesdjojo¹; Nate Stephon¹; Vincent Remcho¹; *John Conley*¹; ¹Oregon State University

Session LL:

Materials Integration: Wafer Bonding and Engineered Substrates

Friday AM
June 24, 2011

Room: Multicultural Center Theatre
Location: University of California-Santa Barbara

Session Chairs: Mark Goorsky, University of California, Los Angeles; Cindy Colinge, Tyndall National Institute

8:20 AM Student

LL1, Electrochemical Etched InP Porous Layer Formation for Layer Transfer: *Xiaolu Kou*¹; Mark Goorsky¹; ¹UCLA

8:40 AM Student

LL2, Ion-cut Transfer of InP-Based High Electron Mobility Transistors Using Adhesive Bonding: *Wayne Chen*¹; Christopher Doran¹; Thomas Kuech²; S Lau¹; ¹UCSD; ²University of Wisconsin, Madison

9:00 AM

LL3, Investigation of PECVD Silicon Nitride Deposition on Porous Si: *Caroline Moulet*¹; Mark Goorsky¹; ¹UCLA

9:20 AM Student

LL4, Double Layer Transfer Made by the Smart Cut™ Technology and Embedded Porous Silicon Layer: *Anne-Sophie Stragier*¹; Thomas Signamarcheix¹; Patrice Gergaud¹; Thierry Salvetat¹; Chrystel Deguet¹; Mustapha Lemiti¹; ¹CEA-LETI

9:40 AM

LL5, LiNbO₃ Thin Single Crystal Layer Transfer by Smart Cut Technology: *Bruno Imbert*¹; Francois de Guerville²; Nicolay Cherkashin²; Vincent Paillard²; Alain Claverie²; Frederic Mazen¹; Chrystel Deguet¹; ¹CEA; ²CEMES

10:00 AM Break

10:20 AM Student

LL6, InGaAs-InGaN Wafer-Bonded Current Aperture Vertical Transistors: *Shalini Lal*¹; Eric Snow¹; Jing Lu¹; Stacia Keller¹; Umesh K. Mishra¹; ¹Department of Electrical and Computer Engineering, University of California, Santa Barbara

10:40 AM

LL7, Electrical Conductivity of Directly Bonded Silicon/Germanium Hetero-Structures: Isabelle Ferain¹; John Hayes¹; Ran Yu¹; Ki Yeol Byun¹; Farzan Gity¹; *Brenda Long*¹; Cindy Colinge¹; ¹Tyndall National Institute

11:00 AM Student

LL8, Interface Barrier Height Reduction in Wafer Bonded n-GaAs / n-GaAs by Sulfur Passivation Methods: *Michael Jackson*¹; Mark Goorsky¹; ¹UCLA Materials Science and Engineering

Technical Program

11:20 AM Student

LL9, Comprehensive Investigation of Ge-Si Bonded Interfaces Using Surface Activation: *Ki Yeol Byun*¹; Isabelle Ferain¹; Brenda Long¹; Susan Holl²; Cindy Colinge¹; ¹Tyndall National Institute; ²California State University

11:40 AM

LL10, 3C-Silicon Carbide Epitaxy by Means of Silicon Carbide-on-Silicon Wafer Bonding: *Michael Jennings*¹; Tony Rogers²; Amador Pérez-Tomas³; Nick Aitken²; Peter Ward⁴; Andrea Severino⁵; Craig Fisher¹; Peter Gammon¹; Philip Mawby¹; ¹University of Warwick; ²Applied Microengineering Limited; ³Centro Nacional de Microelectronica; ⁴PWC; ⁵CNR-IMM

Session MM:

Semiconductor Processing: Oxidation, Passivation, Etching and Contacts

Friday AM Room: Santa Barbara Harbor
June 24, 2011 Location: University of California-Santa Barbara

Session Chairs: Douglas Hall, University of Notre Dame; Thomas Jackson, Pennsylvania State University

8:20 AM Student

MM1, Surface Preparation of GaP for Regrowth on Epitaxially-Inverted Structures on Silicon: *Angie Lin*¹; Martin Fejer¹; James Harris¹; ¹Stanford University

8:40 AM Student

MM2, Oxide Surface Passivation of Ge for Optoelectronic Applications: *William O'Brien*¹; Bin Wu¹; Chad Stephenson¹; Christina Arisio¹; Marya Lieberman¹; Mark Wistey¹; ¹University of Notre Dame

9:00 AM Student

MM3, Oxygen-Enhanced Wet Thermal Oxidation of In_{0.53}Ga_{0.47}As: *Christopher Seibert*¹; Jinyang Li¹; Wangqing Yuan¹; Douglas Hall¹; ¹University of Notre Dame

9:20 AM Student

MM4, Wet Etching Technique for Fabrication of GaSb Based Mid Infrared Single Lateral Mode Lasers: *Seungyong Jung*¹; Sergey Suchalkin²; Leon Shterengas¹; Gela Kipshidze¹; Gregory Belenky¹; ¹Stony Brook University; ²Power Photonics Corporation

9:40 AM Student

MM5, Fabrication of GaAs Micromechanical Resonator Arrays for Single Molecule Detection: *Andrew Hollowell*¹; Christopher Hains¹; Vakhtang Putkaradze²; Mario Marconi²; Larry Dawson¹; Ganesh Balakrishnan¹; ¹University of New Mexico; ²Colorado State University

10:00 AM Break

10:20 AM Student

MM6, Hydrogenated Amorphous Silicon-Carbon Alloy Thin Films for Uncooled Microbolometers: *Hang-Beum Shin*¹; David John¹; MyungYoon Lee¹; Nikolas Podraza¹; Thomas Jackson¹; ¹The Penn State University

10:40 AM

MM7, Metal and Semiconductor Contacts (Si, V, Au) to Organic Molecules: The Fullerene Model System: Harmonie Sahalov¹; Hui Liu¹; *Petra Reinke*¹; ¹University of Virginia

11:00 AM Student

MM8, Silicide/Silicon/Silicide Heterostructures with Ultra-Thin Silicon Gap and Realization of FET Device: *Wei Tang*¹; Shadi Dayeh²; Tom Picraux²; King-Ning Tu²; ¹UCLA; ²Los Alamos National Lab

11:20 AM

MM9, Improved Electrical Properties of N-Contacts to N-Face GaN for Vertical Light-Emitting Diodes by Laser-Annealing: Joon Woo Jeon¹; Sang Youl Lee²; June-O Song²; *Tae-Yeon Seong*¹; ¹Korea University; ²LG Innotek

11:40 AM Student

MM10, Resistance and Transparency Study of Contacts to p-Type GaN: *Wenting Hou*¹; Christoph Stark¹; Theeradetch Detchprohm¹; Christian Wetzel¹; ¹Rensselaer Polytechnic Institute

Session NN:

Molecular Electronics / Sensor / Ionic Conductors

Friday AM Room: State Street
June 24, 2011 Location: University of California-Santa Barbara

Session Chairs: David Janes, Purdue University; Theresa Mayer, Pennsylvania State University

8:20 AM Student

NN1, Au-Molecule-GaAs Devices with Graphene Barrier Layer: *Patrick Carpenter*¹; Ting-Fung Chung¹; David Janes¹; Yong Chen¹; ¹Purdue University

8:40 AM Student

NN2, Gap Mode Plasmonic Cavity with Coupled Organic Gain Medium: *Shanying Cui*¹; Kasey Russell¹; Evelyn Hu¹; ¹Harvard University

9:00 AM

NN3, Conductance Statistics of Molecular Junctions Fabricated with a Large Array of Sub-10 nm Single-Grain Au Nanodots Electrodes: Nicolas Clement¹; Kacem Smaali¹; Gilles Patriarche²; *Dominique Vuillaume*¹; ¹IEMN-CNRS; ²LPN-CNRS

9:20 AM Student

NN4, Surface Functionalization of Si Nanowires on SOI Substrates for Biosensing Applications: *Paul Bertani*¹; Xuejin Wen¹; Wu Lu¹; ¹The Ohio State University

9:40 AM Student

NN5, Switching Characteristics of Nonvolatile Organic Resistive Memory Devices with Interfacial Oxide Layers Tuned by O₂ Plasma Treatment: *Byungjin Cho*¹; Sunghoon Song¹; Yongsung Ji¹; Takhee Lee¹; ¹Gwangju Institute of Science and Technology

10:00 AM Break

10:20 AM Student

NN6, Synthesis and Lithium Battery Applications of Nitrogen Doped Graphene Films: *Leela Mohana Reddy Arava*¹; Anchal Srevestava¹; Sanketh Gowda¹; Hemtej Gullapalli¹; Madan Dubey²; Pulickel Ajayan¹; ¹Rice University; ²U.S. Army Research Laboratory

10:40 AM Student

NN7, Conformal Coating of Thin Polymer Electrolyte Layer on Nanostructured Electrode Materials for 3D Battery Applications: Sanketh Gowda¹; *Leela Mohana Reddy Arava*¹; Pulickel Ajayan¹; ¹Rice University

11:00 AM Student

NN8, Nanostructured Co₃O₄ Supercapacitors via Solution Precursor Plasma Spray: *Raghavender Tummala*¹; Ramesh K. Guduru¹; Pravansu Mohanty¹; ¹University of Michigan

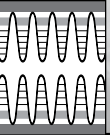
11:20 AM Student

NN9, Performance of MnO₂ Crystallographic Phases in Rechargeable Lithium-Air Oxygen Cathode: *Olubukun Oloniyo*¹; ¹Newcastle University

11:40 AM

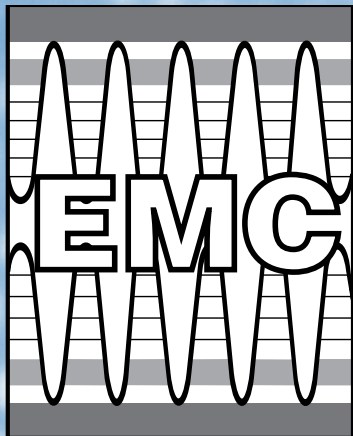
NN10, Investigation on Activated Charcoal-Carbon Fabrics Composite Electrode Materials for Supercapacitor Application: *Amrita Jain*¹; Ashish Gupta¹; Manju Mishra²; S.K. Tripathi¹; ¹Jaypee University of Engineering and Technology; ²Viva Institute of Technology

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NOTES

PRELIMINARY



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Questions?

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